SEARCH REQUEST FORM

Scientific and Technical Information Center

•	P. 7 1		
Requester's Full Name:	Sin J. Lee	Examiner # : 76060 33 Serial Number:	Date: 12-8-05
Art: Unit: 1752 Phone N Mail Box and Bldg/Room Location	1umber 30 <u>C-13</u>	33 Serial Number: Results Format Preferred (circle)	10 / 103, 990
Wan Box and Didg/Room Location	(Rem.)		AT EN DIOR 'E-MAIL
lf:more\than one search\is\subm	itted, please p ric		eed. **********
Please provide a detailed statement of the Include the elected species or structures, k utility of the invention. Define any terms	eywords, synonyms, that may have a speci	acronyms, and registry numbers, and o al meaning. Give examples or relevar	combine with the concept or
known. Please attach a copy of the cover s	heet, pertinent claims	s, and abstract.	•
Title of Invention:			
Inventors (please provide full names):_		·	
a.	·		·
Earliest Priority Filing Date:		· 	••
For Sequence Searches Only Please includ appropriate serial number.	le all pertinent informa	tion (parent, child, divisional, or issued p	atent numbers) along with the
uppropriate serial number.		•	
			•
Please search to	ir the		•
Please search for	£ . 60	nula (I)	•
compound	69 . 100		
		•	
m c1. ‡	‡ 3	•	•
•	·		•
-	-		
			· .
		SCIENTIFIC REFERENCE BR	
	:	DEC 8 ncc	
		Pat. & T.M. Office	
		. and Tivit Office	
•	-		
•			
	•		
			,
********	*****	*****	*******
STAFF USE ONLY	Type of Search	Vendors and cost wh	rere:applicable
Searcher: Ed	NA Sequence (#)	\$TN\$911_77	
Searcher Phone #:	A'A Sequence (#)	- Dialog	
Searcher Location:	Structure (#)	Questel/Orbit	
Date Searcher Picked Up:	Bibliographic	or Link	
Date Completed: 12-9-05	Litigation	Lexis/Nexis	
Searcher Prep & Review/Time:	/ Fulltext	Sequence Systems	·
Clerical Prep Time.	Patent Family	WWW/Internet	· ·
Online Time: 120	Other	Other (specify)	

PTO-1590 (8-01)

=> file reg FILE 'REGISTRY' ENTERED AT 11:05:33 ON 09 DEC 2005 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2005 American Chemical Society (ACS)

=> d his

```
FILE 'LREGISTRY' ENTERED AT 08:56:37 ON 09 DEC 2005
L1
                STR
     FILE 'REGISTRY' ENTERED AT 09:08:02 ON 09 DEC 2005
L2
              0 S L1
     FILE 'LREGISTRY' ENTERED AT 09:08:19 ON 09 DEC 2005
                STR
L3
     FILE 'REGISTRY' ENTERED AT 09:10:17 ON 09 DEC 2005
L4
              0 S L3
                SCR 1840
L5
              2 S L3 AND L5
L6
                SCR 1139
L7
              8 S L3 AND L5 AND L7
^{18}
L9
               STR L3
             8 S L9 AND L5 AND L7
L10
              STR L9
L11
             5 S L11 AND L5 AND L7
L12
L13
               STR
L14
             2 S (L11 NOT L13) AND L5 AND L7
            301 S (L11 NOT L13) AND L5 AND L7 FUL
L15
                SAV L15 LEE990/A
     FILE 'HCAPLUS' ENTERED AT 09:34:06 ON 09 DEC 2005
L16
           4752 S BARR ?/AU
L17
           1595 S FAHEY ?/AU
          11754 S CONNOR ?/AU OR O CONNOR ?/AU OR OCONNOR ?/AU
L18
             81 S PISKORSKI ?/AU
L19
L20
              0 S L16 AND L17 AND L18 AND L19
              0 S L16 AND L17 AND L19
L21
            506 S BARR R?/AU
L22
L23
           468 S FAHEY J?/AU
           1233 S CONNOR C?/AU OR O CONNOR C?/AU OR OCONNOR C?/AU
L24
L25
             33 S PISKORSKI J?/AU
        45667 S IMAGING#/TI
L26
L27
             10 S (L22 OR L23 OR L24 OR L25) AND L26
```

L28 L29 L30 L31	0 S L27 AND L28 8 S (L22 OR L23 OR L24 OR L25) AND L28
L32	FILE 'REGISTRY' ENTERED AT 09:41:21 ON 09 DEC 2005 11 S E1-E11
L33	FILE 'LREGISTRY' ENTERED AT 09:43:30 ON 09 DEC 2005 STR L11
L34 L35 L36 L37 L38 L39 L40 L41	FILE 'REGISTRY' ENTERED AT 09:48:58 ON 09 DEC 2005 4 S (L33 NOT L13) AND L5 AND L7 SCR 2043 1 S (L33 NOT L13) AND L5 AND L7 NOT L35 SCR 1993 0 S (L33 NOT L13) AND L5 AND L7 AND L37 SCR 1015 6 S (L33 NOT L13) AND L5 AND L7 AND L39 528 S (L33 NOT L13) AND L5 AND L7 AND L39 FUL SAV L41 LEE990/A
L42	FILE 'HCA' ENTERED AT 09:57:40 ON 09 DEC 2005 350 S L41
L43	FILE 'REGISTRY' ENTERED AT 09:57:47 ON 09 DEC 2005 2 S L41 AND L32
L44	FILE 'HCA' ENTERED AT 09:58:07 ON 09 DEC 2005 60 S L43
L45	FILE 'REGISTRY' ENTERED AT 10:00:11 ON 09 DEC 2005 E QUINONE/CN 1 S E3
L46	FILE 'HCA' ENTERED AT 10:05:07 ON 09 DEC 2005 189527 S L45 OR ?QUINON?
L47	FILE 'LREGISTRY' ENTERED AT 10:05:24 ON 09 DEC 2005 STR
L48 L49 L50 L51 L52	FILE 'REGISTRY' ENTERED AT 10:08:13 ON 09 DEC 2005 21 S L47

```
SCR 2043
L53
          27 S L47 AND L49 AND L51 NOT L53
L54
         13214 S L47 AND L49 AND L51 NOT L53 FUL
L55
                SAV TEMP L55 LEE990A/A
     FILE 'HCA' ENTERED AT 10:14:14 ON 09 DEC 2005
          49933 S L55
L56
L57
            12 S L42 AND L46
L58
              9 S L42 AND L56
              1 S L57 AND L58
L59
     FILE 'LREGISTRY' ENTERED AT 10:17:33 ON 09 DEC 2005
L60
                STR
     FILE 'REGISTRY' ENTERED AT 10:18:37 ON 09 DEC 2005
             50 S L60
L61
          34956 S L60 FUL
L62
                SAV TEM L62 LEE990C/A
     FILE 'HCA' ENTERED AT 11:00:17 ON 09 DEC 2005
          50026 S L62
L63
L64
             1 S L42 AND (L46 OR L63) AND L56
             14 S L42 AND (L46 OR L63)
L65
             9 S L42 AND L56
L66
             1 S L59 OR L64
L67
             9 S L58 OR L66
L68
             8 S L68 NOT L67
L69
            13 S (L57 OR L65) NOT (L67 OR L69)
L70
     FILE 'REGISTRY' ENTERED AT 11:05:33 ON 09 DEC 2005
```

=> d 141 que stat

L5 SCR 1840 L7 SCR 1139 L13 STR

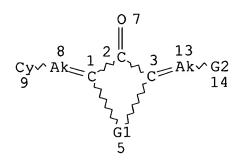
G1 1 N=N

G1 1 N=N NO2 @8 @4 5

VAR G1=4/8 NODE ATTRIBUTES: DEFAULT MLEVEL IS ATOM DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:
RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 4

STEREO ATTRIBUTES: NONE L33 STR



Hy @20 Cb-√N @23 24

REP G1=(0-5) C
VAR G2=20/23
NODE ATTRIBUTES:
NSPEC IS RC AT 24
DEFAULT MLEVEL IS ATOM
GGCAT IS UNS AT 9
DEFAULT ECLEVEL IS LIMITED
ECOUNT IS M1 N AT 20

GRAPH ATTRIBUTES:

RING(S) ARE ISOLATED OR EMBEDDED NUMBER OF NODES IS 12

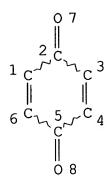
STEREO ATTRIBUTES: NONE L39 SCR 1015

L41 528 SEA FILE=REGISTRY SSS FUL (L33 NOT L13) AND L5 AND L7 AND L39

100.0% PROCESSED 103042 ITERATIONS SEARCH TIME: 00.00.02

528 ANSWERS

=> d 162 que stat L60 STR



NODE ATTRIBUTES:
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES: RING(S) ARE ISOLATED OR EMBEDDED NUMBER OF NODES IS 8

STEREO ATTRIBUTES: NONE L62 34956 SEA FILE=REGISTRY SSS FUL L60

100.0% PROCESSED 972786 ITERATIONS SEARCH TIME: 00.00.04

34956 ANSWERS

=> d 155 que stat
L47 STR

11
0
|
N^CH2-CH2^O-Ak
1 2 3 4 5

NODE ATTRIBUTES:
CONNECT IS E2 RC AT 5
DEFAULT MLEVEL IS ATOM
DEFAULT ECLEVEL IS LIMITED

GRAPH ATTRIBUTES:
RING(S) ARE ISOLATED OR EMBEDDED
NUMBER OF NODES IS 6

STEREO ATTRIBUTES: NONE

SCR 1312 L49 L51 SCR 1235 AND 1297 SCR 2043 L53 13214 SEA FILE=REGISTRY SSS FUL L47 AND L49 AND L51 NOT L53 L55

100.0% PROCESSED 813845 ITERATIONS

13214 ANSWERS

SEARCH TIME: 00.00.29

=> file hca FILE 'HCA' ENTERED AT 11:11:26 ON 09 DEC 2005 USE IS SUBJECT TO THE TERMS OF YOUR STN CUSTOMER AGREEMENT. PLEASE SEE "HELP USAGETERMS" FOR DETAILS. COPYRIGHT (C) 2005 AMERICAN CHEMICAL SOCIETY (ACS)

=> d 167 1 all hitstr

ANSWER 1 OF 1 HCA COPYRIGHT 2005 ACS on STN L67

AN 130:274092 HCA

Entered STN: 08 May 1999 ED

Resist pattern formation process TΙ

Tanaka, Akira; Koshiyama, Masami; Sakamoto, Kei; Yoneda, Yasuhiro; IN Yokouchi, Kishio; Mizutani, Daisuke; Ishizuki, Yoshikatsu

Nippon Zeon Co., Ltd., Japan; Fujitsu Limited PA

U.S., 17 pp., Cont.-in-part of U.S. 5,777,068. SO CODEN: USXXAM

DT Patent

LA English

ICM C08G073-00 IC

ICS G03F007-037

INCL 528353000

74-5 (Radiation Chemistry, Photochemistry, and Photographic and CC Other Reprographic Processes)

Section cross-reference(s): 76

FAN.CNT 3

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
ΡI	 US 5886136	А	19990323	us 1997-819111	199703
	US 5777068	A	19980707	US 1995-527057	17 199509
	JP 09258441	A2	19971003	JP 1996-90244	12

```
199603
                                                                   19
                                20041020
     JP 3579534
                         B2
PRAI US 1995-527057
                        A2
                                19950912
     JP 1996-90244
                         Α
                                19960319
     JP 1994-247109
                        Α
                                19940913
     JP 1994-256222
                      Α
                                19940926
CLASS
                CLASS PATENT FAMILY CLASSIFICATION CODES
 PATENT NO.
 US 5886136
                 ICM
                        C08G073-00
                 ICS
                        G03F007-037
                 INCL
                        528353000
                        528/353.000; 430/170.000; 430/175.000;
US 5886136
                NCL
                        430/270.100; 430/281.100, 430/283.100;
                        430/286.100; 430/289.100; 430/297.000;
                        430/299.000; 528/170.000
                        C08G073/10B1D; C08G973/10B1P; G03F007/037
                 ECLA
                        528/353.000; 524/600.000; 524/607.000;
                 NCL
US 5777068
                        528/125.000; 528/126.000; 528/128.000;
                        528/172.000; 528/173.000; 528/179.000;
                        528/188.000; $28/220.000; 528/229.000;
                        528/350.000
                        G03F007/03/
                 ECLA
     Disclosed herein is a resist pattern formation process in
AΒ
     semiconductor fabrication comprising the steps of coating a
     substrate with a photores/ist compn. comprising a polyamic acid
     having, at each termina / thereof, an actinic ray-sensitive
     functional group which has substituent groups each having a
     photopolymerizable carbon-carbon double bond, a photosensitive
     compd. having a photopolymerizable functional group, a photopolymn.
     initiator, and a solvent to form a layer, subjecting the layer to
     patterning exposure, and developing the thus-exposed layer with an
     alk. developer or alk. aq. soln.
     photoresist polyamic acid photopolymerizable group
ST
IT
     Polyamic acids
        (contg. photopolymerizable carbon-carbon double bonds for
        photoresists for fabrication of semiconductor devices)
IT
     Photoresists
        (contg. polyamic compds. contg. photopolymerizable carbon-carbon
        double bonds)
IT
     Semiconductor devices
        (photoresists contg. photopolymerizable carbon-carbon double
        bonds for fabrication of)
     79-10-7, 2-Propenoic acid, uses 79-41-4, uses
                                                       80-62-6
                                                                 84-11-7,
ΙT
    Phenanthrenequinone 84-47-9, 2-tert-
    Butylanthraquinone 84-65-1, Anthraquinone
     90-93-7, 4,4'-Bis(diethylamino)benzophenone 90-94-8, Michler's
```

97-63-2, Ethyl 96-33-3 96-05-9, Allyl methacrylate ketone 98-86-2. methacrylate 97-86-9, Isobutyl methacrylate 97-88-1 101-43-9, Cyclohexyl methacrylate Acetophenone, uses 105-16-8, Diethylaminoethyl methacrylate 106-63-8, 106-90-1, Glycidyl acrylate Isobutyl acrylate 106-74-1 119-61-9, Benzophenone, uses 119-53-9, Benzoin 120-12-7, Anthracene, uses 140-88-5 141-32-2, Butyl acrylate 492-22-8, Thioxanthone 688-84-6, 2-Ethylhexyl methacrylate 689-12-3, Isopropyl acrylate 752-56-7, Riboflavin tetrabutyrate 868-77-9 882-33-7, Diphenyl disulfide 925-60-0, 818-61-1 Propyl acrylate 947-19-3, 1-Hydroxycyclohexylphenyl ketone 999-55-3, Allyl acrylate 1070-70-8, 959-52-4, Triacrylformal 1,4-Butylene glycol diacrylate 1189-08-8, 1,3-Butylene glycol 1680-21-3, Triethylene glycol diacrylate dimethacrylate 1985-51-9, Neopentyl glycol dimethacrylate 2157-01-9, Octyl 2210-28-8, Propyl methacrylate 2223-82-7, Neopentyl methacrvlate 2370-63-0, Ethoxyethyl methacrylate 2399-48-6, glycol diacrylate Tetrahydrofurfuryl acrylate 2426-54-2, Diethylaminoethyl acrylate 2439-35-2, Dimethylaminoethyl acrylate 2455-24-5, Tetrahydrofurfuryl methacrylate 2478-10-6 2495-35-4, 2498-66-0, 1,2-Benzo-9,10-Benzyl acrylate 2495-37-6 anthraquinone 2530-85-0 **2867-47-2**, Dimethylaminoethyl methacrylate 3066-70-4 3066-71-5, Cyclohexyl acrylate 3121-61-7, Methoxyethyl acrylate 3253-41-6, Tetramethylolmethane tetramethacrylate 3290-92-4 3524-62-7, 3524-68-3, Pentaerythritol triacrylate Benzoin methyl ether 4655-34-9, Isopropyl methacrylate 4986-89-4, 4367-02-6 Tetramethylolmethane tetraacrylate 5495-84-1, 2-5910-25-8 6606-59-3 6652-28-4, Benzoin Isopropylthioxanthone 6976-93-8, Methoxyethyl methacrylate 7024-08-0, isopropyl ether 7024-09-1, Trimethylolpropane Trimethylolpropane monoacrylate 7328-17-8, Carbitol acrylate 7251-90-3 monomethacrylate 13048-33-4 13532-94-0, 2-Butoxyethyl 7794-68-5, 2-Methylbenzoin 15625-89-5, Trimethylolpropane triacrylate methacrylate 16423-68-0, Erythrosine 18977-38-3, 2,6-Bis(p-19727-16-3 dimethylaminobenzylidene) cyclohexanone 19660-16-3 24493-53-6, 1,3-Propylene glycol 22499-11-2, Benzoin butyl ether 24650-42-8, 2,2-Dimethoxy-2-phenylacetophenone diacrylate 25584-83-2, Hydroxypropyl acrylate 25852-47-5 26570-48-9, Poly(ethylene glycol) diacrylate 26846-58-2, Pentaerythritol 27813-02-1, Hydroxypropyl methacrylate dimethacrylate 27936-34-1, Methylanthraquinone 29721-79-7, Hydroxybutyl 37275-47-1, Trimethylolpropane diacrylate methacrylate 41223-11-4 41637-38-1 41996-78-5, Benzyldiethyl 40220-08-4 53417-29-1, Pentaerythritol diacrylate 51989-01-6 ketal 55205-34-0 55919-77-2, Pentaerythritol monoacrylate 56361-55-8 56744-60-6, 2,2-Bis(4-methacryloxydiethoxyphenyl)propane 57472-68-1, Dipropylene glycol diacrylate 61016-96-4 63226-13-1,

IT

IT

IT

RE

(21) Rubner; US 030186RE 1980 (22) Tokoh; US 5238784 1993 HCA

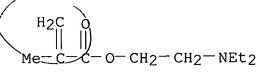
```
3,3'-Carbonylbis(7-diethylaminocoumarin) 64401-02-1
                                                             72700-01-7
     77473-08-6, 3,3',4,4'-Tetrakis(tert-butylperoxycarbonyl)benzophenone
     80548-27-2, Pentaerythritol monomethacrylate
                                                    90981-75-2,
    Acrylorange
                   197011-48-6
                                 221877-38-9 221877-40-3
        (photoresists contg. photosensitive polyamic acids and)
     172652-96-9P, Tris(methacryloyl)pentaerythritol p-aminobenzoate
     172653-01-9P, Tris(methacryloyl)pentaerythritol p-nitrobenzoate
        (prepn. and reaction in prepg. photosensitive polyamic acids for
        photoresists)
     221877-34-5P, 3,3',4,4'-Benzophenonetetracarboxylic acid
    dianhydride-4,4'-diaminodiphenyl ether-tris(methacryloyl)pentaerythr
                                      221877-36-7P, 3,3',4,4'-
     itol p-nitrobenzoate copolymer
     Benzophenonetetracarboxylic dianhydride-4,4'-diaminodiphenyl
     ether-pyromellitic dianhydride-tris(methacryloyl)pentaerythritol
                                221877-37-8P, 3,3',4,4'-
    p-nitrobenzoate copolymer
     Benzophenonetetracarboxylic dianhydride-1,3-bis(3-aminopropyl)-
     1,1,3,3-tetramethyldisiloxane-4,4'-diaminodiphenyl
     ether-pyromellitic dianhydride-tris(methacryloyl)pentaerythritol
    p-nitrobenzoate copolymer
        (prepn. and use in prepg. photoresists)
                                         3524-66-1, Pentaerythritol
     122-04-3, p-Nitrobenzoyl chloride
     trimethacrylate
        (reaction in prepg. photosensitive polyamic acids for
        photoresists)
              THERE ARE 22 CITED REFERENCES AVAILABLE FOR THIS RECORD
RE.CNT
        22
(1) Anon; JP 5530207 1974
(2) Anon; JP 5541422 1976
(3) Anon; JP 5952822 1979
(4) Anon; JP 63183439 1988 HCA
(5) Anon; JP 1259351 1989
(6) Anon; EP 0502400 1992 HCA
(7) Anon; JP 4363361 1992
(8) Anon; JP 470661 1992
(9) Anon; JP 5100424 1993
(10) Anon; JP 5281717 1993
(11) Anon; JP 55995 1993
(12) Anon; EP 0702270 A2 1996 HCA
(13) Anon; JP 8082931 1996
(14) Anon; JP 8095247 1996
(15) Hiramoto; US 4243743 1981 HCA
(16) Kleeberg; US 3957512 1976 HCA
(17) Kubota; J Macromol Sci -Chem 1987, VA24(12), P1407 HCA
(18) Opa; US 5348835 1994 HCA
(19) Opa; US 5518864 1996 HCA
(20) Rubner; US 4040831 1977 HCA
```

105-16-8, Diethylaminoethyl methacrylate 2426-54-2, Diethylaminoethyl acrylate 2439-35-2, Dimethylaminoethyl acrylate 2867-47-2, Dimethylaminoethyl methacrylate 18977-38-3, 2,6-Bis(p-dimethylaminobenzylidene)cyclohexanone 221877-40-3

(photoresists contg. photosensitive polyamic acids and)

RN 105-16-8 HCA

CN 2-Propenoic acid, 2-methyl-, 2-(diethylamino)ethyl ester (9CI) (CA - INDEX NAME)



RN 2426-54-2 HCA

CN 2-Propenoic acid, 2-(digthylamino)ethyl ester (9CI) (CA INDEX NAME)

RN 2439-35-2 HCA

CN 2-Propenoic acid, 2-(dimethylamino)ethyl ester (9CI) (CA INDEX NAME)

$$Me_2N-CH_2-CH_2-O-C$$
 $CH=CH_2$

RN 2867-47-2 H¢A

CN 2-Propenoic acid, 2-methyl-, 2-(dimethylamino)ethyl ester (9CI) (CA INDEX NAME)

RN 18977-38-3 HCA

CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 221877-40-3 HCA

CN Cyclohexanone, 2,6-bis[[4-(diethylamino)phenyl]methylene]-4-phenyl-(9CI) (CA INDEX NAME)

=> d 169 1-8 cbib abs hitstr hitind

L69 ANSWER 1 OF 8 HCA COPYRIGHT 2005 ACS on STN
143:396345 Photoimaging material showing high sensitivity and wide development latitude for direct platemaking of positive-working lithographic printing plate by IR laser. Hatanaka, Yusuke;
Nakamura, Ippei (Fuji Photo Film Co., Ltd., Japan). Jpn. Kokai
Tokkyo Koho JP 2005283680 A2 20051013, 51 pp. (Japanese). CODEN:
JKXXAF. APPLICATION: JP 2004-93801 20040326.

GΙ

Ι

The title photoimaging material comprises water-insol. alkali-sol. resin-contg. image recording layers on a support, wherein the outermost image recording layer contains an IR absorbing agent represented by I (R1-4 = H, alkyl, aryl; R5, R6 = alkyl, substituted oxy, halo; n, m = 0-4; Z1, Z2 = H, alkyl, aryl; Q = trimethine, pentamethine; X- = counter anion).

IT 38394-53-5P 38954-40-4P, 2-(N-Ethylanilino)ethylacetate 80601-02-1P 100609-71-0P 301193-31-7P

(IR absorber prepn. for photoimaging material showing high sensitivity and wide development latitude for direct platemaking of pos.-working lithog. printing plate by IR laser)

RN 38394-53-5 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 38954-40-4 HCA

CN Ethanol, 2-(ethylphenylamino)-, acetate (ester) (9CI) (CA INDEX NAME)

RN 80601-02-1 HCA

CN Cyclohexanone, 2,6-bis[[4-(diethylamino)phenyl]methylene]- (9CI)

(CA INDEX NAME)

RN 100609-71-0 HCA

CN Benzaldehyde, 4-[[2-(acetyloxy)ethyl]ethylamino]- (9CI) (CA INDEX NAME)

RN 301193-31-7 HCA

CN Cyclopentanone, 2-[[4-(diethylamino)phenyl]methylene]-5-[[4-[ethyl(2-hydroxyethyl)amino]phenyl]methylene]- (9CI) (CA INDEX NAME)

IC ICM G03F007-004

ICS G03F007-00; G03F007-095

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 22057-80-3P 38394-53-5P 38954-40-4P,

2-(N-Ethylanilino)ethylacetate 80601-02-1P

100609-71-0P 301193-31-7P

(IR absorber prepn. for photoimaging material showing high sensitivity and wide development latitude for direct platemaking of pos.-working lithog. printing plate by IR laser)

L69 ANSWER 2 OF 8 HCA COPYRIGHT 2005 ACS on STN 136:45708 Image-formation material and infrared absorber. Nakamura,

Ippei (Fuji Photo Film Co., Ltd., Japan). Eur. Pat. Appl. EP 1162078 A2 20011212, 41 pp. DESIGNATED STATES: R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO. (English). CODEN: EPXXDW. APPLICATION: EP 2001-112937 20010606. PRIORITY: JP 2000-169180 20000606.

Heat mode-applicable image-formation materials are described which comprise a substrate carrying thereon an image-formation layer which contains an IR absorbing agent which has .gtoreq.1 surface orientation group in the mol. and for which the soly. of the layer in an alk. aq. soln. is changed by action of radiation in the near-IR range. IR absorbing agents are also described which comprise, in a mol. thereof, a fluorine-contg. substituent which have .gtoreq.5 fluorine atoms, or a polymethine chain of .gtoreq.5 carbon atoms and an alkyl group of .gtoreq.8 carbon atoms, the alkyl group being connected to the polymethine chain via any of nitrogen, oxygen and sulfur. Planog. printing plates including the heat mode-applicable image-formation materials are also described.

IT 38954-40-4P 100609-71-0P 379671-80-4P 379671-81-5P

(IR-sensitive image-forming materials and IR absorbers)

RN 38954-40-4 HCA

AB

CN Ethanol, 2-(ethylphenylamino)-, acetate (ester) (9CI) (CA INDEX NAME)

RN 100609-71-0 HCA

CN Benzaldehyde, 4-[[2-(acetyloxy)ethyl]ethylamino]- (9CI) (CA INDEX NAME)

RN 37967¹-80-4 HCA

CN Cyclohexanone, 2,6-bis[[4-[ethyl(2-hydroxyethyl)amino]phenyl]methyle ne]- (9CI) (CA INDEX NAME)

$$\begin{array}{c} \text{Et} \\ \text{HO-CH}_2\text{-CH}_2\text{-CH}_2\text{-OH} \\ \\ \text{CH-CH}_2\text{-CH}_2\text{-OH} \\ \end{array}$$

RN 379671-81-5 HCA

CN Octanoic acid, pentadecafluoro-, (2-oxo-1,3-cyclohexanediylidene)bis[methylidyne-4,1-phenylene(ethylimino)-2,1-ethanediyl] ester (9CI) (CA INDEX NAME)

PAGE 1-B

IC ICM B41M005-40

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

Section cross-reference(s): 25, 27, 28

IT 38954-40-4P 51740-38-6P 100609-71-0P

379671-80-4P 379671-81-5P

(IR-sensitive image-forming materials and IR absorbers)

L69 ANSWER 3 OF 8 HCA COPYRIGHT 2005 ACS on STN

134:35063 Negative-working IR-sensitive material for direct printing platemaking. Nakamura, Ippei (Fuji Photo Film Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 2000338651 A2 20001208, 29 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1999-151412 19990531.

$$\begin{array}{c|c}
R^{1} \\
R^{2}
\end{array}$$

$$\begin{array}{c|c}
\uparrow \\
X^{-}
\end{array}$$

$$\begin{array}{c|c}
\downarrow \\
R^{5}
\end{array}$$

$$\begin{array}{c|c}
\downarrow \\
Z^{1}
\end{array}$$

$$\begin{array}{c|c}
\downarrow \\
Z^{2}
\end{array}$$

$$\begin{array}{c|c}
\downarrow \\
R^{6}
\end{array}$$

The title IR-sensitive material comprises (a) photo- or thermal-acid generator, (b) acid-activatable crosslinking agent, (c) water-insol., alk.-sol. polymer, and (d) IR-absorbing agent represented by general formula I (R1-4 = H, alkyl, aryl; R5, R6 = alkyl, substituted oxy, halo; n, m = 0-4; Z1, Z2 = H, alkyl, aryl; Q = trimethine, pentamethine; X- = counter anion).

Τ

18977-38-3P, 2,6-Bis (4-dimethylaminobenzylidene) cyclohexanon e 38394-53-5P 38954-40-4P 100609-71-0P 301193-31-7P

(prepn. of IR-absorbing agent for neg.-working IR-sensitive material)

RN 18977-38-3 HCA

CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 38394-53-5 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 38954-40-4 HCA

CN Ethanol, 2-(ethylphenylamino)-, acetate (ester) (9CI) (CA INDEX NAME)

RN 100609-71-0 HCA

CN Benzaldehyde, 4-[[2-(acetyloxy)ethyl]ethylamino]- (9CI) (CA INDEX

RN 301193-31-7 HCA

CN Cyclopentanone, 2-[[4-(diethylamino)phenyl]methylene]-5-[[4-[ethyl(2-hydroxyethyl)amino}phenyl]methylene]- (9CI) (CA INDEX NAME)

IC ICM G03F007-00

ICS B41N001-14; C08K005-13; C08K005-19; C08L101-12; G03F007-004

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 18977-38-3P, 2,6-Bis(4-dimethylaminobenzylidene)cyclohexanon

22057-80-3P **38394-53-5P 38954-40-4P**

100609-71-0P 301193-31-7P

(prepn. of IR-absorbing agent for neg.-working IR-sensitive material)

L69 ANSWER 4 OF 8 HCA COPYRIGHT 2005 ACS on STN

133:303571 IR-laser sensitive composition for lithographic plate making by direct imaging. Nakamura, Ippei (Fuji Photo Film Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 2000275828 A2 20001006, 32 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1999-82401 19990325.

- AB The invention relates to an IR-laser sensitive compn. has an IR absorbing material and a polymer insol. in water and sol. in an alkali soln., wherein the compn. shows the high sensitivity and the high development latitude.
- 38394-53-5P, 2,5-Bis[4-(diethylamino)benzylidene]cyclopentan one 38954-40-4P 80601-02-1P 100609-71-0P 301193-31-7P

(IR absorbing agent in IR-laser sensitive compn.)

RN 38394-53-5 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 38954-40-4 HCA

CN Ethanol, 2-(ethylphenylamino)-, acetate (ester) (9CI) (CA INDEX NAME)

RN 80601-02-1 HCA

CN Cyclohexanone, 2,6-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} & & \\ \hline \\ \text{Et}_2 \text{N} \\ \hline \end{array} \text{O} \begin{array}{c} \text{CH} \\ \hline \\ \text{NEt}_2 \\ \end{array}.$$

RN 100609-71-0 HCA

CN Benzaldehyde, 4-[[2-(acetyloxy)ethyl]ethylamino]- (9CI) (CA INDEX NAME)

RN 301193-31-7 HCA

CN Cyclopentanone, 2-[[4-(diethylamino)phenyl]methylene]-5-[[4-[ethyl(2-hydroxyethyl)amino]phenyl]methylene]- (9CI) (CA INDEX NAME)

$$Et_2N$$
 CH
 CH
 CH
 CH
 CH
 CH

IC ICM G03F007-004

ICS B41N001-14; C09B023-00; G03F007-00; G03F007-027; G03F007-20

CC 74-6 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

IT 10025-87-3P, Phosphoryl chloride 22057-80-3P **38394-53-5P** , 2,5-Bis[4-(diethylamino)benzylidene]cyclopentanone

38954-40-4P 80601-02-1P 100609-71-0P

301193-29-3P **301193-31-7P**

(IR absorbing agent in IR-laser sensitive compn.)

L69 ANSWER 5 OF 8 HCA COPYRIGHT 2005 ACS on STN

130:304033 Photosensitive resin composition. Kato, Hideto (Shin-Etsu Chemical Industry Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 11092660 A2 19990406 Heisei, 8 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1997-276463 19970924.

GΙ

The photosensitive resin compn. comprises (1) 0.01-20 wt. parts of a photopolymn. initiator and (2) 100 wt. parts of a polyimide resin with an av. mol. wt. 5,000-150,000 represented by I (X = tetravalent arom. substituent; Y = divalent arom. substituent; Z = divalent siloxane-contg. substituent; and 0.70.ltoreq.m/(m + n).ltoreq.0.98). The imidation of the resin compn. film can be carried out at .ltoreq.250.degree., and the resulting film exhibits good adhesion with a substrate without corroding a metal. The resin compn. is sued for a LCD orientation film and an insulating film in a semiconductor device and a printed circuit board.

Ι

IT 105-16-8, Diethylaminoethyl methacrylate 65446-47-1 (photopolymn. initiator; photosensitive resin compn.)

RN 105-16-8 /HCA

CN 2-Propendic acid, 2-methyl-, 2-(diethylamino)ethyl ester (9CI) (CA INDEX NAME)

RN 65/46-47-1 HCA

CN Cyclohexanone, 2,6-bis[[4-(diethylamino)phenyl]methylene]-4-methyl-(9CI) (CA INDEX NAME)

$$CH$$
 CH
 CH
 NEt_2

IC ICM C08L079-08

ICS C08K005-00

- CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
 Section cross-reference(s): 37, 76
- IT 103-01-5, N-Phenylglycine 105-16-8, Diethylaminoethyl
 methacrylate 1076-59-1, 3-Phenyl-5-isoxazolone 7189-82-4
 10287-54-4, Ethyl 4-diethylaminobenzoate 63226-13-1
 65446-47-1

(photopolymn. initiator; photosensitive resin compn.)

L69 ANSWER 6 OF 8 HCA COPYRIGHT 2005 ACS on STN
114:196380 Thin-film photoresist composition. Sato, Kuniaki; Kojima,

Yasunori; Kaji, Makoto; Ishimaru, Toshiaki; Hayashi, Nobuyuki; Kojima, Mitsumasa (Hitachi Chemical Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 02157845 A2 19900618 Heisei, 15 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1988-313351 19881212.

GΙ

- AB A thin-film photoresist compn. comprises (1) a photosensitive adduct formed from a polyimide precursor I [R1 = a tetravalent arom. group; R2 = a divalent org. group] and R3R4C:CR5CO2R6NCO [R3, R4, R5 = H, Me; R6 = a divalent hydrocarbon group] or Y1Y2Y3R7OC(O)NHR8NCO [Y1-3 = H, a monovalent org. group with ethylenic unsatn.; R7 = a tetravalent org. group; R8 = a divalent org. group], (2) a photopolymn. initiation system contg. an aminobenzylidenecarbonyl compd. and an N-aryl-.alpha.-amino acid, and (3) an org. solvent. The photoresist compn. has high photosensitivity and good thermal stability and is useful in semiconductor device fabrication.
- IT 133461-65-1

(photopolymn. initiator, photoresist compn. contg.)

- RN 133461-65-1 HCA
- CN 1,4-Cyclohexanedione, 2,6-bis[[4-(diethylamino)phenyl]methylene]-(9CI) (CA INDEX NAME)

CODEN:

```
30674-80-70, adduct with polyamic acid
IT
        (photoresist compn. contg.)
     30674-80-7 HCA
RN
     2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester (9CI)
                                                                  (CA
CN
     INDEX/NAME)
        - O- CH2- CH2- NCO
IC
     ICM G03F007-027
         C08F002-44; C08F002-46; C08G073-10; C08L079-08; G03F007-004;
          G03F007-031; G03F007-038
     74-5 (Radiation Chemistry, Photochemistry, and Photographic and
     Other Reprographic Processes)
     Section cross-reference(s): 76
                 42288-26-6 133461-65-1
     4367-02-6
ΙT
        (photopolymn. initiator, photoresist compn. contg.)
     24980-39-0D, adduct with isocyanide 30674-80-7D, adduct
IT
     with polyamic acid 54554-39-1D, polyamic acid adduct
        (photoresist compn. contg.)
     ANSWER 7 OF 8 HCA COPYRIGHT 2005 ACS on STN
L69
110:240210 Photosensitive resin compositions containing polyamic acid
     esters and oxime compounds. Suga, Nobuhiko; Ikeda, Akihiko; Ai,
```

Hideo (Asahi Chemical Industry Co., Ltd., Japan). Jpn. Kokai Tokkyo

Koho JP 63010612 A2 19880118 Showa, 17 pp. (Japanese).

JKXXAF. APPLICATION: JP 1986-152609 19860701.

GI

$$-x - z - y - z - R1$$

$$(CO_2R)_n (W)_m I$$

$$COC = NO_2CR^3$$

$$SO_2R^2$$
II

The title photosensitive resin compns. contain a polymer with repeating units I [(X = (2+n)-valent carbocycle or heterocycle moiety; Y = (2+m)-valent carbocycle or heterocycle moiety; Z = CONH, NHCONH, O2CNH; R = alkene moiety; W = group capable of reacting with the CO2R group to form a ring; n = 1,2; m = 0,1,2; CO2R group is at o- or p-position with respect to Z position], an oxime compd. of the formula II (R1 = H, C1-6 alkyl, C1-6 alkoxy, NO2; R2 = C1-6 alkoxy, C6-10 aryl, C6-10 aryloxy), and a sensitizer whose absorption max. wavelength is 250-500 nm. Cured patterns from the photosensitive resin compns. have excellent heat-resistance. Thus, an ester of 4,4'-diaminodiphenyl ether-pyromellitic dianhydride copolymer with 2-hydroxyethyl methacrylate 100, PhCOC(SO2Me):NO2CPh 3, and Michlers ketone 3 parts were mixed to give a photosensitive resin compn. having good sensitivity.

IT 105-16-8,/n,n-Diethylaminoethyl methacrylate

(polyamic acid ester-based photoresist compn. contg.)

RN 105-16-8 HCA

CN 2-Propenoic acid, 2-methyl-, 2-(diethylamino)ethyl ester (9CI) (CA INDEX/NAME)

$$H_2C$$
 O
 H_2C O
 Me $C-C-O-CH_2-CH_2-NEt_2$

IT 65446-46-0

(sensitizer, for polyamic acid ester-based photoresist compns.)

RN 65446-46-0 HCA

CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]-4-methyl(9CI) (CA INDEX NAME)

- IC ICM C08F299-00
 - ICS C08F002-48; C08F299-02; G03C001-00; G03C001-68; G03C001-71
- CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
- 86-93-1, 1-Phenyl-5-mercapto-1H-tetrazole 98-29-3, IT p-tert-Butylcatechol 105-16-8, n,n-Diethylaminoethyl 149-30-4, methacrylate 110-26-9, Methylenebisacrylamide 2-Mercaptobenzothiazole 583-39-1, 2-Mercaptobenzimidazole 2897-60-1, Diethoxy-3-glycidyloxypropylmethylsilane 2530-85-0 14513-34-9, 3-Methacryloyloxypropyldimethoxymethylsilane 15625-89-5, Trimethylolpropane triacrylate 17831-71-9, Tetraethylene glycol diacrylate 31432-60-7, N-Nitrodiphenylamine (polyamic acid ester-based photoresist compn. contg.)
- IT 90-93-7, 4,4'-Bis (diethylamino) benzophenone 90-94-8, Michler's ketone 91-44-1 120-07-0, n-Phenyldiethanolamine 1161-22-4, 4,4'-Bis (dimethylamino) chalcone 1628-58-6 5706-20-7 6673-14-9 63226-13-1 65446-46-0

(sensitizer, for polyamic acid ester-based photoresist compns.)

- L69 ANSWER 8 OF 8 HCA COPYRIGHT 2005 ACS on STN
- 94:183456 Photopolymerizable compositions based on salt-forming polymers and polyhydroxy polyethers. Chambers, William J. (du Pont de Nemours, E. I., and Co., USA). U.S. US 4245031 19810113, 16 pp. Cont.-in-part of U.S. Ser. No. 892,296, abandoned. (English). CODEN: USXXAM. APPLICATION: US 1979-76621 19790918.
- GI For diagram(s), see printed CA Issue.
- Photopolymerizable compns. contg. a polymer having a plurality of AΒ salt-forming groups, an ethylenically unsatd. compd. have .gtoreq.1 complementary salt-forming group, an ethylenically unsatd. diester polyhydroxy polyether of the structure I (R = H or Me; R1 = H or C1-4 alkyl group; n = 1-15; p = 0 or 1; and when p is 1, R2 is H or Me, and R3 is H, Me or Et), and a radiation-sensitive, free-radical generating system provide photopolymerizable elements which have outstanding photospeeds and are relatively insensitive to 0. a mixt. of 2.5 parts polyamide resin (Versamid 125), 4.0 parts itaconic acid, 1.0 part Epocryl 12, 0.3 part benzophenone, 0.3 part 2-(o-chlorophenyl)-4,5-diphenylimidazolyl dimer, 0.25 part Michler's ketone and 0.05 part C.I. Solvent Red Dye #109 was dissolved in a mixt. of 20 parts methanol and 10 parts 2-butoxyethanol, spin-coated onto anodized Al supports (2000 rpm for 0.75 min), exposed for 1 s in air to a 275-W sunlamp held 7.5 in. away from the samples through a 21-step step wedge process transparency in which the transmittance of radiation between steps differs by a factor of .sqroot.2, developed for 10 s in H2O to show 3 steps, dampened with AGE (asphaltum gum arabic emulsion), dampened with fountain soln., and then inked with a std. black lithog. printing ink to give a good print after pressing directly on paper.

IT 2867-47-2 38394-52-4

(photoimaging photopolymerizable compn. contg., rapid-speed)

RN 2867-47-2 HCA

CN 2-Propenoic acid, 2-methyl-, 2-(dimethylamino)ethyl ester (9CI) (CA INDEX NAME)

RN 38394-52-4 / HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)-2-methylphenyl]methylene](9CI) (CA INDEX NAME)

IC G03C001-68

INCL 430288000

CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic Processes)

90-94-8 97-65-4, uses IT 57-11-4, uses and miscellaneous 84-51-5 100-43/6 106-10-5 119-61-9, uses and and miscellaneous miscellaneous 123-31-9, uses and miscellaneous 149-30-4 1707-68-2 **2867-47-2** 621-82-9, uses and miscellaneous 9011-14-7 20357-25-9 22499-12-3 9002-89-5 9011-13-6 25135-39-1 25232-41-1 29729-87-1 25014-15-7 25086**-**15**-**1 37300-17-7 37331-99-0 29777-36-4 36425-15/7 37189-83-6 38394-52-4 53814-24-7 70431-39-9

(photoimaging phøtopolymerizable compn. contg., rapid-speed)

=> d 170 1-13 cbib abs/hitstr hitind

L70 ANSWER 1 OF 13 /HCA COPYRIGHT 2005 ACS on STN

143:164942 Electron emitters having high emission efficiency and photocurable compositions therefor. You, Seung-Joon; Kim, Jae-Myung; Nam, Joong-Woo; Lee, Soo-Kyung; Moon, Jong-Woon; Lee, Hyun-Joon (Samsung SDI Co., Ltd., S. Korea). Jpn. Kokai Tokkyo Koho JP 2005197247 A2 20050721, 14 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 2004-369872 20041221. PRIORITY: KR 2004-1476 20040109.

- AB Compns. contg. org. binder resins, carbon substances, solvents, silane compds. R'SiR3 [R = alkyl, alkoxy, Cl, F, Br; R' = vinyl, epoxy, methacryl, amino, mercapto, or 2-(3,4-epoxycyclohexyl)ethyl], and optionally glass frits are claimed. Compns. contg. carbon substances, solvents, photosensitive monomers, photosensitive polymers/oligomers, photopolymn. initiators, and the silanes as above, are further claimed. The compns. are printed on substrates to form electron emitters with good adhesion to substrates. Further claimed are field emission displays holding the emitters, phosphor films, and black matrix patterns.
- RN 18977-38-3 HCA CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

- RN 65446-46-0 HCA
- CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]-4-methyl-(9CI) (CA INDEX NAME)

$$\begin{array}{c} \text{Me} \\ \text{CH} \\ \text{C} \\ \text{NMe} \\ \text{2} \\ \text{N} \end{array}$$

- RN 261360-66-1 HCA
- CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]-, (2E,5E)- (9CI) (CA INDEX NAME)

Double bond geometry as shown.

IC ICM H01J031-12 ICS H01J001-304; H01J009-02; H01J029-04

CC 76-11 (Electric Phenomena)
Section cross-reference(s): 74

84-47-9, 2-tert-Butylanthraquinone 82-05-3, Benzanthrone IT 84-65-1, Anthraquinone 86-39-5, 2-Chlorothioxanthone 90-94-8 92-50-2 90-44-8, Anthrone 90-93-7 90-98-2 119-53-9, Benzoin 119-61-9, 102-04-5, Dibenzyl ketone 131-09-9, 122-98-5, N-Phenylethanolamine Benzophenone, uses .beta.-Chloroanthraquinone 486-25-9, Fluorenone 606-28-0, Methyl o-benzoylbenzoate 492-22-8, Thioxanthone 1210-35-1, Dibenzosuberone 2179-02-4 3077-12-1 1161-22-4 4159-04-0, Methylene anthrone 3524-62-7, Benzoin methyl ether 5284-79-7, 2,6-Bis(p-azidobenzylidene)-4-methylcyclohexanone 5495-84-1, 2-Isopropylthioxanthone 5706-20-7 6175-45-7, 7473-98-5, 2-Hydroxy-2-methyl 2,2-Diethoxyacetophenone 6767-30-2 propiophenone 13936-21-5, 2-Amylanthraquinone 15774-82-0, 2-Methylthioxanthone **18977-38/3** 20237-98-3, 2,6-Bis(p-azidobenzylidene)cyclohexanone/ 21431-38-9 22499-11-2, 24650-42-8, 2,2-Dimethoxy-2-phenylacetophenone Benzoin butyl ether 41657-71-0, 4-Azidobenzalacetophenone / 42391-37-7 50807-17-5 63226-13-1, 3,3-Carbony bis (7-diethylaminocoumarin) 55163-72-9 63757-55-1 **65446-46-0** 69677-75-4 / 82612-95-1, Isoamyl 100752-97-4, Diethylthioxanthone dimethylaminobenzoate 124187-69-5 136482-23-0 **261360/66-1** (photopolymn. initiators; fixeld emission cathodes formed from

L70 ANSWER 2 OF 13 HCA COPYRYGHT 2005 ACS on STN

display substrates)

143:162740 High-efficiency norresonant two-photon-absorbing organic materials and their applications. Akiba, Masaharu; Tani, Takeharu; Morinaga, Naoki; Takizawa, Hiroo (Fuji Photo Film Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 2005195922 A2 20050721, 69 pp. (Japanese). CODEN: JXXXAF. APPLICATION: JP 2004-2743 20040108.

AB The materials contain TPAD1L(TPAD2)n (I; TPAD1, TPAD2 = group contg.

carbon pastes contg. sp. sixlanes and showing good adhesion to

AB The materials contain TPAD1L(TPAD2)n (I; TPAD1, TPAD2 = group contg. nonresonant two-photon-absorbing chromophore; L = linkage, single bond, atom; n = 1-7). Preferably, the TPAD1 and TPAD2 are cyanine

dyes, streptocyanine dyes, merocyanine dyes, oxonol dyes, stilbazolium dye, or groups contg. X2(CR4:CR3)mC:Y(CR1:CR2)nX1 [R1-R4 = H, substituent: Y = O, at. group contg. CN, COMe, SO2, etc.; X1, X2 = aryl, heterocyclyl, 5- or 6-membered azacyclic group (structure given); m, n = 0-4; m = n .noteq. 0;]. The materials are useful for luminescent materials, polymerizable compns., optical recording materials, and image forming materials, which are irradiated with laser at wavelength longer than linear absorption band of I in actual use.

IT 718636-51-2P

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

RN 718636-51-2 HCA

CN 1H-Indole-5-carboxylic acid, 2-[4-[3-[4-(1,3-dihydro-3,3-dimethyl-1-pentyl-2H-indol-2-ylidene)-2-butenylidene]-2-oxocyclopentylidene]-2-butenylidene]-2,3-dihydro-1,3,3-trimethyl- (9CI) (CA INDEX NAME)

PAGE 1-B

__ CO2H

IT 859500-49-5P 859500-50-8P

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

RN 859500-49-5 HCA

CN 1H-Indole-5-carboxylic acid, 2-[4-[3-[4-(1,3-dihydro-3,3-dimethyl-1-pentyl-2H-indol-2-ylidene)-2-butenylidene]-2-oxocyclopentylidene]-2-butenylidene]-2,3-dihydro-1,3,3-trimethyl-, 1,4-phenylene ester (9CI) (CA INDEX NAME)

PAGE 1-A

PAGE 1-B

PAGE 1-C

$$= CH - CH$$

$$(CH2)4 - Me$$

RN 859500-50-8 HCA

CN 1H-Indole-5-carboxamide, N,N'-1,2-cyclohexanediylbis[2-[4-[3-[4-(1,3-dihydro-3,3-dimethyl-1-pentyl-2H-indol-2-ylidene)-2-butenylidene]-2-oxocyclopentylidene]-2-butenylidene]-2,3-dihydro-1,3,3-trimethyl-(9CI) (CA INDEX NAME)

PAGE 1-A

PAGE 1-B

IT 859500-51-9 859500-52-0

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

RN 859500-51-9 HCA

CN 1H-Indole-5-carboxylic acid, 2-[4-[3-[4-(1,3-dihydro-3,3-dimethyl-1-pentyl-2H-indol-2-ylidene)-2-butenylidene]-2-oxocyclopentylidene]-2-butenylidene]-2,3-dihydro-1,3,3-trimethyl-, 1,3-phenylene ester (9CI) (CA INDEX NAME)

PAGE 1-B

PAGE 1-C

RN 859500-52-0 HCA

CN 1H-Indole-5-carboxamide, N,N'-1,4-cyclohexanediylbis[2-[4-[3-[4-(1,3-dihydro-3,3-dimethyl-1-pentyl-2H-indol-2-ylidene)-2-butenylidene]-2-oxocyclopentylidene]-2-butenylidene]-2,3-dihydro-1,3,3-trimethyl-(9CI) (CA INDEX NAME)

PAGE 1-A

PAGE 1-B

PAGE 1-C

IC ICM G02F001-361 ICS C08K005-00; C08L101-00; C09K011-06; G11B007-24; C09B023-00

- CC 73-10 (Optical, Electron, and Mass Spectroscopy and Other Related Properties)
 - Section cross-reference(s): 27, 38, 74
- IT **718636-51-2P** 859500-47-3P

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

- IT 859500-49-5P 859500-50-8P
 - (high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)
- 120-92-3D, Cyclopentanone, cyclopentanone 123-31-9, **Hydroquinone**, reactions 694-83-7, 1,2-Cyclohexanediamine 681836-46-4 859500-48-4

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

IT 859500-51-9 859500-52-0

(high-efficiency nonresonant two-photon-absorbing org. materials for luminescent materials, polymerizable compns., optical recording materials, and image forming materials)

- L70 ANSWER 3 OF 13 HCA COPYRIGHT 2005 ACS on STN
- 129:217399 Manufacture of photosensitive polyimide precursors and their compositions having stable viscosity. Yoshikawa, Haruhiko; Takemoto, Kazunari; Tanaka, Osamu; Isoda, Keiko; Uchimura, Shunichiro; Kaji, Makoto; Kanao, Osamu (Hitachi, Ltd., Japan; Hitachi Chemical Co., Ltd.). Jpn. Kokai Tokkyo Koho JP 10204176 A2 19980804 Heisei, 26 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1997-10941 19970124.
- The polyimide precursors representing repeating units AΒ [COR1(CO2R3)2CONHR2AnNH] (R1 = C.gtoreq.4 tetravalent org. groups; R2 = trivalent or tetravalent org. groups contg. arom. rings; R3 = monovalent org. groups; A = acidic monovalent groups; n = 1, 2) and having Mw 10,000-200,000, are prepd. in the presence of hardly water-sol. polymn. inhibitors. The compns., useful for photoresists or elec. packaging, etc., the polyimide precursors 100, sensitizers 0.1-50, and photopolymn. assistants 0.1-50 parts. Thus, acid chloride prepd. from 3,3',4,4'-biphenyltetracarboxylic acid dianhydride, 2-hydroxyethyl methacrylate, and thionyl chloride, was reacted with 3,5-diaminobenzoic acid in the presence of 3,5-di-tert-butylcatechol to give a polyimide precursor (Mw calcd. as polystyrene 44,000), 10 q of which was mixed with 100 mg 3,5-bis(4-diethylaminobenzylidene)-1-methyl-4-azacyclohexanone and 200 mg 4-diethylaminoethyl benzoate to give a compn. showing viscosity at 25.degree. 4.50 mPas and 4.60 mPas before and after 1-wk storage at room temp, resp. Then, a coating film prepd. by applying the compn. to a silicon wafer, was exposed to 365 nm-UV

radiation at 200 mJ/cm2, developed, and cured at 200.degree. for 30 min and 400.degree. for 60 min to give a polyimide film showing elongation 9% and sensitivity 80 mJ/cm2.

IT 844-51-9, 2,5-Diphenyl-p-benzoquinone

(polymn. inhibitor; manuf. of photosensitive polyimide precursors compns.)

- RN 844-51-9 HCA
- CN 2,5-Cyclohexadiene-1,4-dione, 2,5-diphenyl- (9CI) (CA INDEX NAME)

IT **212136-95-3**

(sensitizers; manuf. of photosensitive polyimide precursors compns.)

- RN 212136-95-3 HCA
- CN Cyclohexanecarboxylic acid, 3,5-bis[[4-(dimethylamino)phenyl]methyle ne]-4-oxo- (9CI) (CA INDEX NAME)

- IC ICM C08G073-10
- CC 37-6 (Plastics Manufacture and Processing)

Section cross-reference(s): 74

IT **844-51-9**, 2,5-Diphenyl-p-benzoquinone 1020-31-1, 3,5-Di-tert-butylcatechol 1898-66-4 31432-60-7, N-Nitrodiphenyl amine

(polymn. inhibitor; manuf. of photosensitive polyimide precursors compns.)

- IT 82-05-3, Benzanthrone 90-94-8, Michler's ketone 91-44-1, 7-Diethylamino-4-methylcoumarin 4367-02-6 82799-44-8,
 - 2,4-Diethylthioxanthone **212136-95-3** (sensitizers; manuf. of photosensitive po

(sensitizers; manuf. of photosensitive polyimide precursors compns.)

L70 ANSWER 4 OF 13 HCA COPYRIGHT 2005 ACS on STN

- 122:147304 Photodefinable polymers containing perfluorocyclobutane groups. Babb, David A.; Richey, W. Frank; Clement, Katherine S.; Moyer, Eric S.; Sorenson, Marius W. (Dow Chemical Co., USA). PCT Int. Appl. WO 9415258 A1 19940707, 75 pp. DESIGNATED STATES: W: CA, JP, KR; RW: AT, BE, CH, DE, DK, ES, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE. (English). CODEN: PIXXD2. APPLICATION: WO 1993-US11562 19931201. PRIORITY: US 1992-996452 19921224.
- AB The title polymer has .gtoreq.1 photoactive site and >1 perfluorocyclobutane group. New monomers contg. photoactive sites or photoactive precursors and .gtoreq.1 perfluorovinyl group are useful for making such polymers. Processes of making such polymers and the monomers from which they are made are disclosed. The polymers are useful in coatings, photoresists, and other photoactive applications.
- 161250-47-1, 2-(4-Aminobenzylidene)-6-(4-trifluoroethenyloxybenzylidene)cyclohexanone 161250-48-2, 2-(4-Aminobenzylidene)-6-(4-trifluoroethenyloxybenzylidene)-4-methylcyclohexanone 161250-51-7, 2-(4-Isocyanatobenzylidene)-5-(4-trifluoroethenyloxybenzylidene)cyclohexanone 161250-52-8, 2-(4-Isocyanatobenzylidene)-6-(4-trifluoroethenyloxybenzylidene)-4-methylcyclohexanone (monomer for photodefinable polymer)
- (monomer for photodefinable polymer)
 RN 161250-47-1 HCA
- CN Cyclohexanone, 2-[(4-aminophenyl)methylene]-6-[[4-[(trifluoroethenyl)oxy]phenyl]methylene]- (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} & & & \\ &$$

- RN 161250-48-2 HCA
- CN Cyclohexanone, 2-[(4-aminophenyl)methylene]-4-methyl-6-[[4-[(trifluoroethenyl)oxy]phenyl]methylene]- (9CI) (CA INDEX NAME)

$$\begin{array}{c|c} & \text{Me} \\ \hline \\ \text{H}_2\text{N} \\ \hline \end{array} \\ \begin{array}{c|c} \text{CH} \\ \hline \\ \text{O} \\ \hline \end{array} \\ \begin{array}{c|c} \text{CF}_2 \\ \hline \\ \text{O} \\ \hline \end{array} \\ \end{array}$$

RN 161250-51-7 HCA

CN Cyclohexanone, 2-[(4-isocyanatophenyl)methylene]-6-[[4-[(trifluoroethenyl)oxy]phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 161250-52-8 HCA

CN Cyclohexanone, 2-[(4-isocyanatophenyl)methylene]-4-methyl-6-[[4-[(trifluoroethenyl)oxy]phenyl]methylene]- (9CI) (CA INDEX NAME)

IC ICM G03F007-004

ICS C07C043-17; C08F016-32

CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)
Section cross-reference(s): 35

IT 161249-96-3 161249-98-5 161249-99-6 161250-00-6,

.beta.-(4-Hydroxybenzylidene)-4-(trifluoroethenyloxy)acetophenone

161250-01-7, .beta.-(4-Acetylbenzylidene)-4-

(trifluoroethenyloxy) acetophenone 161250-02-8,

.beta. - (4-Acetyloxybenzylidene) -4-(trifluoroethenyloxy) acetophenone

161250-03-9, .beta.-(4-Aminobenzylidene)-4-

(trifluoroethenyloxy)acetophenone 161250-04-0,

.beta.-(4-Carboxybenzylidene)-4-(trifluoroethenyloxy)acetophenone

161250-05-1, .beta.-(4-Isocyanatobenzylidene)-4-

(trifluoroethenyloxy) acetophenone 161250-06-2,

.beta.-(4-Chlorocarboxybenzylidene)-4-(trifluoroethenyloxy)acetophen

one 161250-07-3, .beta.-(4-Carboxymethylbenzylidene)-4-

(trifluoroethenyloxy) acetophenone 161250-08-4,

.beta.-(4-Carboxyethylbenzylidene)-4-(trifluoroethenyloxy)acetopheno ne 161250-09-5, 4-Hydroxy-.beta.-(4-trifluoroethenyloxybenzylidene

)acetophenone 161250-10-8, 4-Amino-.beta.-(4-

trifluoroethenyloxybenzylidene)acetophenone 161250-11-9,

```
4-Carboxy-.beta.-(4-trifluoroethenyloxybenzylidene)acetophenone
161250-12-0, 4-Chlorocarboxy-.beta.-(4-trifluoroethenyloxybenzyliden
                 161250-13-1, 4-Isocyanato-.beta.-(4-
e)acetophenone
trifluoroethenyloxybenzylidene)acetophenone
                                              161250-14-2,
4-Carboxymethyl-.beta.-(4-trifluoroethenyloxybenzylidene)acetophenon
                  161250-16-4, 1-(4-Hydroxyphenyl)-2-(4-
    161250-15-3
trifluoroethenyloxyphenyl)-1-propene
                                       161250-17-5,
2-(4-Hydroxyphenyl)-1-(4-trifluoroethenyloxyphenyl)-1-propene
161250-18-6, 1-(4-Aminophenyl)-2-(4-trifluoroethenyloxyphenyl)-1-
          161250-19-7, 2-(4-Aminophenyl)-1-(4-
propene
                                       161250-20-0,
trifluoroethenyloxyphenyl)-1-propene
1-(4-Carboxyphenyl)-2-(4-trifluoroethenyloxyphenyl)-1-propene
161250-21-1, 2-(4-Carboxyphenyl)-1-(4-trifluoroethenyloxyphenyl)-1-
          161250-22-2, 1-(4-Chlorocarboxyphenyl)-2-(4-
propene
trifluoroethenvloxyphenyl)-1-propene
                                       161250-23-3,
2-(4-Chlorocarboxyphenyl)-1-(4-trifluoroethenyloxyphenyl)-1-propene
161250-24-4, 1-(4-Isocyanatophenyl)-2-(4-trifluoroethenyloxyphenyl)-
           161250-25-5, 2-(4-Isocyanatophenyl)-1-(4-
1-propene
trifluoroethenyloxyphenyl)-1-propene
                                       161250-26-6,
1-(4-Carboxymethylphenyl)-2-(4-trifluoroethenyloxyphenyl)-1-propene
              161250-28-8, 4-Hydroxy-4'-trifluoroethenyloxystibene
161250-27-7
161250-29-9, 4-Aminophenyl-4'-trifluoroethenyloxystilbene
161250-30-2, 4-Carboxyphenyl-4'-trifluoroethenyloxystilbene
161250-31-3, 4-Isocyanato-4'-trifluoroethenyloxystilbene
161250-32-4, 4-Carboxymethylphenyl-4'-trifluoroethenyloxystilbene
161250-33-5, 5-Hydroxy-8-trifluoroethenyloxynaphthoquinone
161250-34-6, 1-(4-Hydroxyphenyl)-5-(4-trifluoroethenyloxyphenyl)-1,4-
pentadien-3-one
                  161250-35-7, 1-(4-Aminophenyl)-5-(4-
trifluoroethenyloxyphenyl)-1,4-pentadien-3-one
                                                 161250-36-8,
1-(4-Carboxyphenyl)-5-(4-trifluoroethenyloxyphenyl)-1,4-pentadien-3-
                    161250-38-0, 1-(4-Isocyanatophenyl)-5-(4-
      161250-37-9
trifluoroethenyloxyphenyl)-1,4-pentadien-3-one
                                                 161250-39-1,
5-Hydroxy-8-trifluoroethenyloxycoumarin
                                          161250-40-4,
8-Hydroxy-5-trifluoroethenyloxycoumarin
                                          161250-41-5,
5-Amino-8-trifluoroethenyloxycoumarin
                                        161250-42-6,
                                        161250-43-7,
8-Amino-5-trifluoroethenyloxycoumarin
5-Isocyanato-8-trifluoroethenyloxycoumarin
                                             161250-44-8,
                                             161250-45-9,
8-Isocyanato-5-trifluoroethenyloxycoumarin
2-(4-Hydroxybenzylidene)-6-(4-trifluoroethenyloxybenzylidene)cyclohe
         161250-46-0, 2-(4-Hydroxybenzylidene)-6-(4-
trifluoroethenyloxybenzylidene)-4-methylcyclohexanone
161250-47-1, 2-(4-Aminobenzylidene)-6-(4-
trifluoroethenyloxybenzylidene)cyclohexanone 161250-48-2,
2-(4-Aminobenzylidene)-6-(4-trifluoroethenyloxybenzylidene)-4-
                     161250-49-3, 2-(4-Carboxymethylbenzylidene)-6-
methylcyclohexanone
(4-trifluoroethenyloxybenzylidene)cyclohexanone
                                                  161250-50-6,
2-(4-Carboxymethylbenzylidene)-6-(4-trifluoroethenyloxybenzylidene)-
4-methylcyclohexanone 161250-51-7, 2-(4-
```

Isocyanatobenzylidene)-5-(4-trifluoroethenyloxybenzylidene)cyclohexa none 161250-52-8, 2-(4-Isocyanatobenzylidene)-6-(4-161250-53-9 trifluoroethenyloxybenzylidene) - 4-methylcyclohexanone 161250-54-0, 2-(4-Chlorocarboxybenzylidene)-6-(4trifluoroethenyloxybenzylidene) -4-methylcyclohexanone 161250-55-1, 1-(4-Acroyloxyphenyl)-1,1-bis(4-trifluoroethenyloxyphenyl)ethane 161250-56-2, 1-(4-Methacroyloxyphenyl)-1,1-bis(4-161250-57-3, 1-(4-Acroylphenyl)trifluoroethenyloxyphenyl)ethane 1,1-bis(4-trifluoroethenyloxyphenyl)ethane 161250-58-4, 1-(4-Methacroylphenyl)-1,1-bis(4-trifluoroethenyloxyphenyl)ethane 161250-61-9 161250-62-0, 161250-59-5 161250-60-8 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)-.beta.-(4trifluoromethylbenzylidene)acetophenone 161250-63-1, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)-.beta.-(4-161250-65-3, carboxymethylbenzylidene)acetophenone 161250-64-2 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)-.beta.-(4chlorobenzylidene)acetophenone 161250-66-4, 4-(1,1-Bis(4trifluoroethenyloxyphenyl)ethyl)-.beta.-(4-161250-67-5, 4-(1,1-Bis(4fluorobenzylidene) acetophenone trifluoroethenyloxyphenyl)ethyl)-.beta.-(4acetylbenzylidene)acetophenone 161250-68-6 161250-69-7, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)styrene 161250-70-0, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)-N-phenylmaleimide 161250-71-1, 1-(4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenyl)-161250-72-2, 1-(4-(1,1-Bis(4-5-phenyl-1,4-pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-(dimethylamino)phenyl)-1,4-pentadiene-3-one 161250-73-3, 1-(4-(1,1-Bis(4trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-methoxyphenyl)-1,4-161250-74-4, 1-(4-(1,1-Bis(4pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-(carboxymethyl)phenyl)-161250-75-5, 1-(4-(1,1-Bis(4-1,4-pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-(carboxyethyl)phenyl)-1-161250-76-6, 1-(4-(1,1-Bis(4-4-pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-(trifluoromethyl)phenyl)-1,4-pentadiene-3-one 161250-77-7, 1-(4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4nitrophenyl)1,4-pentadiene-3-one 161250-78-8, 1-(4-(1,1-Bis(4trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-chlorophenyl)-1,4-161250-79-9, 1-(4-(1,1-Bis(4pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-fluorophenyl)-1,4-161250-80-2, 1-(4-(1,1-Bis(4pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-acetophenyl)-1,4-161250-81-3, 1-(4-(1,1-Bis(4pentadiene-3-one trifluoroethenyloxyphenyl)ethyl)phenyl)-5-(4-cyanophenyl)-1,4pentadiene-3-one 161250-82-4, 4-(1,1-Bis(4trifluoroethenyloxyphenyl)ethyl)phenylacetylene 161250-83-5, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenylbuta-1,3-diyne 161250-84-6, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenylhexa-

```
1,3,5-triyne
               161250-85-7, 4-(1,1-Bis(4-
trifluoroethenyloxyphenyl)ethyl)phenylocta-1,3,5,7-tetrayne
161250-86-8, 4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenyl-
1,3,5,7,9-pentayne
                     161250-87-9, 6-(4-(1,1-Bis(4-
trifluoroethenyloxyphenyl)ethyl)phenoxy)naphthoquinone
161250-88-0, 6-(4-(1,1-Bis(4-trifluoroethenyloxyphenyl)ethyl)phenoxy
            161250-89-1, 7-(4-(1,1-Bis(4-
trifluoroethenyloxyphenyl)ethyl)phenoxy)coumarin
                                                    161250-90-4,
2-(4-(1,1-Bis(trifluoroethenyloxyphenyl)ethyl)benzylidene)cyclohexan
      161250-91-5, 2-(4-(4-(1,1-Bis(trifluoroethenyloxyphenyl)ethyl)
phenoxy) benzylidene) cyclohexanone
                                    161250-92-6,
1-Acroyloxy-2-(4-trifluoroethenyloxy) benzoyloxyethane
                                                         161250-93-7,
1-Methacroyloxy-2-(4-trifluoroethenyloxy) benzoyloxyethane
161250-94-8, N-(4-Trifluoroethenyloxyphenyl)acrylamide
161250-95-9, N-(4-Trifluoroethenyloxyphenyl)methacrylamide
161250-96-0, 4-Trifluoroethenyloxyphenylacrylate
                                                    161250-97-1,
4-Trifluoroethenyloxyphenylmethacrylate
                                           161250-98-2,
N-(4-Trifluoroethenyloxyphenyl) maleimide
                                            161250-99-3,
N-(4-Trifluoroethenyloxybenzoyl)maleimide
                                             161251-00-9
              161251-02-1
                            161251-03-2
                                           161251-04-3
                                                         161251-05-4
161251-01-0
                            161251-08-7
                                           161251-09-8
                                                         161251-10-1
161251-06-5
              161251-07-6
                                           161251-14-5
                                                         161251-15-6
                            161251-13-4
161251-11-2
              161251-12-3
                            161251-18-9
                                           161251-19-0
                                                         161251-20-3
161251-16-7
              161251-17-8
                                           161251-24-7
                                                         161251-25-8
              161251-22-5
                            161251-23-6
161251-21-4
                                                         161251-30-5
161251-26-9
              161251-27-0
                            161251-28-1
                                           161251-29-2
                                           161251-34-9
                                                         161251-35-0
              161251-32-7
                            161251-33-8
161251-31-6
                                           161251-39-4
                            161251-38-3
                                                         161251-40-7
161251-36-1
              161251-37-2
                                           161251-44-1
                                                         161251-45-2
              161251-42-9
                            161251-43-0
161251-41-8
                                                         161251-50-9
                                           161251-49-6
161251-46-3
              161251-47-4
                            161251-48-5
              161251-52-1
                            161251-53-2
                                           161251-54-3,
161251-51-0
1-(4-Fluorophenyl)-2-(4-trifluoroethenyloxyphenyl)-1-propene
161251-55-4, 2-(4-Fluorophenyl)-1-(4-trifluoroethenyloxyphenyl)-1-
          161251-56-5, 1-(4-Cyanophenyl)-2-(4-
trifluoroethenyloxyphenyl)-1-propene
                                       161251-57-6,
2-(4-Cyanophenyl)-1-(4-trifluoroethenyloxyphenyl)-1-propene
161251-58-7, 2-(4-Acetylphenyl)-1-(4-trifluoroethenyloxyphenyl)-1-
          161251-59-8, 4-Methoxy-4'-trifluoroethenyloxystilbene
propene
161251-60-1, 4-Dimethylaminophenyl-4'-trifluoroethenyloxystilbene
161251-61-2, 4-Carboxyethylphenyl-4'-trifluoroethenyloxystilbene
161251-62-3, 4-Nitro-4'-trifluoroethenyloxystilbene
                                                       161251-63-4,
                                           161251-64-5,
4-Chloro-4'-trifluoroethenyloxystilbene
4-Fluoro-4'-trifluoroethenyloxystilbene
                                           161251-65-6,
4-Cyano-4'-trifluoroethenyloxystilbene
                                          161251-66-7,
4-Acetyl-4'-trifluoroethenyloxystilbene
                                           161251-67-8,
                                                    161251-68-9
4-Trifluoromethyl-4'-trifluoroethenyloxystilbene
                                           161251-72-5
                            161251-71-4
                                                         161251-73-6
161251-69-0
              161251-70-3
161251-74-7
              161251-75-8
                            161251-76-9
                                           161251-77-0
                                                         161251-78-1,
1,1-Bis(4-trifluoroethenyloxyphenyl)-1(4-(5-(2-furanyl)-2,4-
```

```
161251-79-2, 3,5-
    pentadiene-1-onyl) phenyl) ethane
    Bis(trifluoroethenyloxy) -. beta. - (benzylidene) acetophenone
    161251-80-5, 3,5-Bis(trifluoroethenyloxy)-.beta.-(4'-
    methoxybenzylidene) acetophenone 161251-81-6, 3,5-
    Bis(trifluoroethenyloxy) -. beta. - (4'-dimethylaminobenzylidene) acetoph
            161251-82-7, 3,5-Bis(trifluoroethenyloxy)-.beta.-(4'-
                                     161251-83-8, 3,5-
    cyanobenzylidene) acetophenone
    Bis(trifluoroethenyloxy)-.beta.-(4'-nitrobenzylidene)acetophenone
                                                              161251-88-3
                                 161251-86-1
                                               161251-87-2
    161251-84-9
                   161251-85-0
                                               161251-92-9
                                                              161251-93-0
                   161251-90-7
                                 161251-91-8
    161251-89-4
                   161251-95-2
                                               161251-97-4,
    161251-94-1
                                 161251-96-3
    2,7-Bis(3-phenyl-2-propene-1-onyl)-9,9-bis(4-
                                                         161251-99-6,
    trifluoroethenyloxyphenyl)fluorene
                                          161251-98-5
    2,7-Bis(3-(2-methoxyphenyl)-2-propene-1-onyl)-9,9-bis(4-
                                          161252-00-2,
    trifluoroethenyloxyphenyl)fluorene
    2,7-Bis(3-(4-dimethylaminophenyl)-2-propene-1-onyl)-9,9-bis(4-
    trifluoroethenyloxyphenyl) fluorene
                                          161252-01-3,
    2,7-Bis(3-(4-cyanophenyl)-2-propene-1-onyl)-9,9-bis(4-
    trifluoroethenyloxyphenyl)fluorene
                                          161252-02-4,
    2,7-Bis(3-(4-nitrophenyl)-2-propene-1-onyl)-9,9-bis(4-
                                                        161252-04-6
    trifluoroethenyloxyphenyl)fluorene
                                          161252-03-5
     161252-05-7, 2-(5-(2-Methoxyphenyl)-2,4-pentadiene-1-onyl)-9,9-bis(4-
     trifluoroethenyloxyphenyl)fluorene
                                          161252-06-8 161252-07-9,
     2,7-Bis(5-(4-cyanophenyl)-2,4-pentadiene-1-onyl)-9,9-bis(4-
                                          161252-08-0,
     trifluoroethenyloxyphenyl)fluorene
     2,7-Bis(5-(4-nitrophenyl)-2,4-pentadiene-1-onyl)-9,9-bis(4-
     trifluoroethenyloxyphenyl)fluorene
                                          161252-09-1,
     2,7-Bis(5-(2-dimethylaminophenyl)-2,4-pentadiene-1-onyl)-9,9-bis(4-
                                                        161252-11-5
                                          161252-10-4
     trifluoroethenyloxyphenyl)fluorene
                                               161252-15-9
                                                              161252-16-0
                   161252-13-7
                                 161252-14-8
     161252-12-6
                                                              161252-22-8
                                 161252-20-6
                                               161252-21-7
     161252-17-1
                   161252-19-3
        (monomer for photodefinable polymer)
     ANSWER 5 OF 13 HCA COPYRIGHT 2005 ACS on STN
118:126497 Polyketomethine dyes and their use. Albert, Bernhard;
```

Kessel, Knut; Martin, Hans Dieter; Silber, Stefan (BASF A.-G., Ger. Offen. DE 4111159 A1 19921008, 19 pp. (German). Germany). APPLICATION: DE 1991-4111159 19910406. CODEN: GWXXBX. The title dyes, R1(:CHCH:)mA(:CHCH:)nR2R3 (A = 2,4,5-AB cyclopentanetrione-1,3-diylidene, 2,3,5,6-cyclohexanetetrone-1,4diylidene; R1 = 0, S, and/or N heterocycle contg. 1 or 2 heteroatoms; R2, R3 = C1-10-alkyl or R2R3 = R1; m, n = 0-3), are obtained for use as pharmaceuticals, sensitizers for electrophotog. or photopolymn., singlet O generators, or in optical recording Thus, 5 mmol 3-methyl-2-(methylthio)benzothiazolium iodide media. was condensed 30 min with 2.5 mol 1,2,4-cyclopentanetrione in refluxing EtOH to give 42% 3,5-bis(3-methyl-2-benzothiazolinylidene)-

L70

1,2,4-cyclopentanetrione.

IT **615-94-1**

(condensation of, with active Me or methylene compds.)

RN 615-94-1 HCA

CN 2,5-Cyclohexadiene-1,4-dione, 2,5-dihydroxy- (9CI) (CA INDEX NAME)

IT 146228-70-8P 146228-71-9P 146228-72-0P

146228-73-1P 146228-74-2P 146228-75-3P

146228-76-4P 146228-77-5P

(prepn. and optical adsorption of)

RN 146228-70-8 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(3-ethyl-2(3H)-benzothiazolylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-71-9 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(3-ethyl-2(3H)-benzoxazolylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-72-0 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(1-ethyl-4(1H)-quinolinylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-73-1 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(1-ethyl-2(1H)-quinolinylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-74-2 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(1-ethyl-1,3-dihydro-3,3-dimethyl-2H-indol-2-ylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-75-3 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(1,3-dihydro-1,3,3-trimethyl-2H-indol-2-ylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-76-4 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[(5-chloro-1-ethyl-1,3-dihydro-3,3-dimethyl-2H-indol-2-ylidene)ethylidene]- (9CI) (CA INDEX NAME)

RN 146228-77-5 HCA

CN 1,2,4-Cyclopentanetrione, 3,5-bis[[5-chloro-1,3-dihydro-3,3-dimethyl-1-(1-methylethyl)-2H-indol-2-ylidene]ethylidene]- (9CI) (CA INDEX NAME)

IC ICM C09B023-01

ICS A61K031-44; A61K031-40; A61K031-425; A61K031-645; C01B013-02; G11B007-24; G03G005-09; C08F002-50

ICA C09D007-12

CC 41-11 (Dyes, Organic Pigments, Fluorescent Brighteners, and Photographic Sensitizers)
Section cross-reference(s): 63, 74

IT **615-94-1** 4539-56-4 15849-14-6, 1,2,4-Cyclopentanetrione 146229-02-9 146229-03-0

(condensation of, with active Me or methylene compds.)

IT 146228-65-1P 146228-66-2P 146228-67-3P 146228-68-4P 146228-69-5P **146228-70-8P 146228-71-9P**

146228-72-0P 146228-73-1P 146228-74-2P 146228-75-3P 146228-76-4P 146228-77-5P

146228-78-6P	146228-79-7P	146228-80-0P	146228-81-1P
146228-82-2P	146228-83-3P	146228-84-4P	146228-85-5P
146228-86-6P	146228-87-7P	146228-88-8P	146228-89-9P
146228-90-2P	146228-91-3P	146228-92-4P	146228-93-5P
146228-94-6P	146228-95-7P	146228-96-8P	146228-97-9P
146228-98-0P	146228-99-1P	146229-00-7P	146425-46-9P
(prepn. ar	nd optical adsorp	ption of)	

L70 ANSWER 6 OF 13 HCA COPYRIGHT 2005 ACS on STN

113:42468 Benzofuran dyes having long wavelength absorption. Chen, Chin Hsin; Fox, John Leonard (Eastman Kodak Co., USA). Eur. Pat. Appl. EP 341567 A2 19891115, 18 pp. DESIGNATED STATES: R: AT, BE, CH, DE, ES, FR, GB, GR, IT, LI, LU, NL, SE. (English). CODEN: EPXXDW. APPLICATION: EP 1989-108015 19890503. PRIORITY: US 1988-191948 19880509.

GI

$$R^{1}$$
 R^{4}
 R^{4}
 R^{3}
 R^{2}
 R^{5}
 $CH = Z$
 I

The title compds. I (R1, R2, R5 = H, aryl, alkyl; R3, R4 = alkyl; Z = electron-withdrawing group; .gtoreq.1 of R1R4, R2R3, and R3R4 completes a 5- or 6-membered ring), useful as fluorescent dyes or as free-radical polymn. coinitiators, are prepd. Thus, 9-formyl-2,3,6,7-tetrahydro-1H,5H-benzo[ij]furano[3,2-g]quinolizine was condensed with 3-cyano-4-phenyl-2-furanone, producing 3-cyano-4-phenyl-5-(2,3,6,7-tetrahydro-1H,5H-benzo[ij]furano[3,2-g]quinolizin-9-ylmethylene)-2-furanone, .lambda.max (CH2Cl2) 655 nm (.epsilon. = 52 .times. 103).

IT 126174-24-1P

(manuf. of, as fluorescent dye and polymn. initiator)

RN 126174-24-1 HCA

CN Cyclopentanone, 2,5-bis[(2,3,6,7-tetrahydro-1H,5H-benzofuro[5,6,7-ij]quinolizin-10-yl)methylene]- (9CI) (CA INDEX NAME)

IT 118-75-2, reactions

(oxidn. by, of (diethylamino) (hydroxymethyl)benzofuran)

RN 118-75-2 HCA

CN 2,5-Cyclohexadiene-1,4-dione, 2,3,5,6-tetrachloro- (9CI) (CA INDEX NAME)

$$\begin{array}{c} C1 \\ C1 \\ C1 \\ \end{array}$$

IC ICM C09B023-00

CC 41-5 (Dyes, Organic Pigments, Fluorescent Brighteners, and Photographic Sensitizers)

Section cross-reference(s): 35

IT 126174-14-9P 126174-15-0P 126174-16-1P 126174-21-8P 126174-23-0P **126174-24-1P** 126174-25-2P 126174-26-3P 126591-49-9P 126845-60-1P 128320-60-5P

(manuf. of, as fluorescent dye and polymn. initiator)

IT **118-75-2**, reactions

(oxidn. by, of (diethylamino)(hydroxymethyl)benzofuran)

L70 ANSWER 7 OF 13 HCA COPYRIGHT 2005 ACS on STN

112:100740 Photopolymerization initiator and thermal-transfer recording medium. Okuma, Norio (Canon K. K., Japan; Sanyo Chemical Industries Ltd.). Jpn. Kokai Tokkyo Koho JP 01174503 A2 19890711 Heisei, 17 pp. (Japanese). CODEN: JKXXAF. APPLICATION: JP 1987-335732 19871228.

GI

$$Ar^{1}CH = C$$

$$X$$

$$I$$

$$Ar^{1}CH = C$$

$$X$$

$$I$$

The title photopolymn. initiator is composed of .alpha.-diketone deriv., and I or II [Ar1, Ar2 arom. ring, heterocyclic ring; R1 = H, C1-10 alkyl, alkenyl, alkoxy, or alkylthio, C6-12 aryl, aryloxy, or heterocyclic ring with no. of C and non-C atoms to be 5-15; X = non-metallic atom for forming a ring]. The thermal-transfer recording layer is composed of the photoinitiator, and monomer, oligomer or polymer with unsatd. double bond or these mixt. An image-forming material my be encapsulated. The initiator is esp. useful in one-shot color recording.

IT 18977-38-3 21889-12-3 38394-53-5 125407-22-9 125407-24-1 125407-25-2

(photopolymn. initiator compn. contg. .alpha.-diketone and) 18977-38-3 HCA

RN 18977-38-3 HCA
CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]- (9CI)
(CA INDEX NAME)

RN 21889-12-3 HCA

CN 2H-Inden-2-one, 1,3-bis[[4-(dimethylamino)phenyl]methylene]-1,3-dihydro- (9CI) (CA INDEX NAME)

RN 38394-53-5 HCA CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

$$CH$$
 CH
 CH
 NEt_2

RN 125407-22-9 HCA

CN Cyclopentanone, 2,5-bis[[4-(1-piperidinyl)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 125407-24-1 HCA

CN 2H-Inden-2-one, 1,3-dihydro-1,3-bis[[4-(4-morpholinyl)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 125407-25-2 HCA

CN Cyclohexanone, 2,6-bis[[4-(1-pyrrolidinyl)phenyl]methylene]- (9CI) (CA INDEX NAME)

IC ICM C08F002-50

ICS G03C001-00; G03C001-68

CC 42-2 (Coatings, Inks, and Related Products)

Section cross-reference(s): 35

IT 10373-78-1, Camphorquinone 108586-95-4

(photopolymn. initiator compn. contg. cyclic ketone and)

IT 5447-53-0 6275-32-7 **18977-38-3 21889-12-3**

38394-53-5 49629-37-0 87384-01-8 125407-04-7

125407-20-7 125407-21-8 **125407-22-9** 125407-23-0

125407-24-1 125407-25-2

(photopolymn. initiator compn. contg. .alpha.-diketone and)

L70 ANSWER 8 OF 13 HCA COPYRIGHT 2005 ACS on STN

103:62585 Photosensitive resin composition. (Nippon Foil Mfg. Co., Ltd., Japan). Jpn. Kokai Tokkyo Koho JP 60028648 A2 19850213 Showa, 8 pp.

(Japanese). CODEN: JKXXAF. APPLICATION: JP 1983-137954 19830726. A photosensitive resin compn. contains a chelating agent 10-4-5% of AΒ the total solid matter. The resin compn. is used for photolithog., photorelief printing, and as photoresist with esp. high storage stability. Thus, a mixt. contg. Me methacrylate 45, styrene 10, acrylic acid 40, poly(butadiene glycol) (G-1000) 5, and azobisisobutyronitrile 2 g was dropwise added to butyl Cellosolve 400 g at 80.degree.. After copolymn., p-diazodiphenylamine-HCHO condensate esterified by a benzenensulfonic acid deriv. 60, Oil Blue 603 0.05, EDTA 1.6, and butyl Cellosolve 240 g were successively added, stirred for 3 h, and filtered. A photosensitive resin compn. was prepd. by mixing the above filtrate 250, iso-PrOH 1500, xylene 200, EtOAc 200, diethylene glycol diacrylate 10, 1,2benzanthraguinone 3.4, benzoin Me ether 0.1, and hydroquinone 0.1 g. The photosensitive plate prepd. by coating the compn. was stored at 60.degree. and 90% relative humidity. Daily sampling of the material and development showed signs of deterioration (scum formation, loss of reproducibility, and defective ink reception) after 21 days storage. A control material without the chelating agent produced these defects after 5 days storage.

IT 38394-52-4

(photoresist compn. contg.)

RN 38394-52-4 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)-2-methylphenyl]methylene](9CI) (CA INDEX NAME)

IC ICM G03C001-00

ICS C08K005-09; C08K005-16; G03F007-00

CC 74-5 (Radiation Chemistry, Photochemistry, and Photographic and Other Reprographic Processes)

79-10-7, uses and miscellaneous 79-10-7D, polymers with hydroxy-terminated polybutadiene, Me methacrylate, and styrene 80-62-6D, polymers with acrylic acid, hydroxy-terminated polybutadiene, and styrene 100-42-5D, polymers with acrylic acid, hydroxy-terminated polybutadiene, and Me methacrylate 1680-21-3 15625-89-5 25085-99-8 25176-75-4 26589-39-9 38394-52-4 97515-91-8

(photoresist compn. contg.)

L70 ANSWER 9 OF 13 HCA COPYRIGHT 2005 ACS on STN
95:178713 Photopolymerizable composition containing an O-nitroaromatic compound as photoinhibitor. Pazos, Jose F. (du Pont de Nemours, E. I., and Co. , USA). Can. CA 1103084 19810616, 61 pp. (English).
CODEN: CAXXA4. APPLICATION: CA 1977-273994 19770315.

A photopolymerizable compn. and process for the prodn. of pos. AΒ images are described. In the process a photopolymerizable compn. contg. a normally nongaseous, ethylenically unsatd. compd. capable of addn. polymn. by free-radical initiated chain propagation, a nitroarom. compd. of formula I (R1-R4 = H, OH, halogen, NO2, CN, C1-18 alkyl, C1-18 alkoxy, aryl, PhCH2, halophenyl, polyether radical, dialkylamino, thioalkyl, thioaryl, or any 2 of R1-R4 together form a benzene ring and .ltoreq.1 of R1-R4 is OH or NO2; R5 = H, C1-18 alkyl, halogen, Ph, C1-18 alkoxy; R6 = H, OH, C1-18 alkyl, Ph, C1-18 alkoxy; or R5R6 together as O, CH6, NPh, or similar devalent group), and an org., radiation-sensitive, free radical-generating system activatable by actinic radiation that does not significantly rearrange the nitroarom. compd. to an inhibitor of free radical polymn. is coated on a suitable support, imagewise exposed through a transparency to radiation, .gtoreq.20% of which has a wavelength of .apprx.200 to .apprx.380 nm to rearrange at least some of the nitroarom. compd. to a polymn.-inhibiting nitroso arom. compd., then exposed to radiation with a wavelength of >380 nm to produce a pos polymer image, and then developed by an appropriate means to give a pos. polymeric image. Thus, a typical photopolymerizable compn contained 1,1,1-trimethylolpropane triacrylate (contg. hydroquinone and/or methylhydroguinone 200 ppm) 3.5 mL, o-nitrobenzyl alc 0.153,

IT 38394-52-4

CN

(photopolymerizable photoimaging compns. contg. nitro compd. photoinhibitor and, for pos. image prodn.)

RN 38394-52-4 HCA

and phenanthrenequinone 0.021 g.

Cyclopentanone, 2,5-bis[[4-(diethylamino)-2-methylphenyl]methylene]-

(9CI) (CA INDEX NAME)

IC G03C001-70; G03C005-24

CC 74-8 (Radiation Chemistry, Photochemistry, and Photographic Processes)

IT 84-11-7 95-71-6 106-10-5 109-16-0 111-21-7 123-31-9, uses and miscellaneous 128-37-0, uses and miscellaneous 150-76-5 603-48-5 1241-94-7 1680-21-3 149-30-4 7440-44-0, uses and miscellaneous 9011-14-7 3524-68-3 25176-75-4 25135-39-1 15625-89-5 24620-40-4 25086-15-1 34122-40-2 **38394-52-4** 39279-99-7 29777-36-4 58206-31-8 53802-03-2

(photopolymerizable photoimaging compns. contg. nitro compd. photoinhibitor and, for pos. image prodn.)

L70 ANSWER 10 OF 13 HCA COPYRIGHT 2005 ACS on STN 94:93573 Photopolymerizable composition containing an o-nitroaromatic compound as photoinhibitor. (du Pont de Nemours, E. I., and Co., USA). Belg. BE 881232 19800718, 12 pp. Addn. to Belg. 852,517. (French). CODEN: BEXXAL. APPLICATION: BE 1980-199028 19800118.

Ι

AB o-Nitro arom. compds. (I; R-R3 = H, OH, halogen, NO2, CN, C1-18 alkyl, C1-18 alkoxy, C6-18 aryl, PhCH2, halophenyl, a polyether group, dialkylamino, alkylthio, arylthio; R4 = H, C1-18 alkyl, halogen, Ph, C1-18 alkoxy, and the like; R5 = H, OH, C1-18 alkyl, Ph, alkoxy, and the like) are described for use as photoinhibitors in photopolymerizable compns. for the prodn. of lithog. plates. Thus, a soln. of methacrylic acid-Me methacrylate copolymer 60.86,

trimethylolpropane triacrylate (contg. 235-265 ppm hydroquinone) 21.31, triethylene glycol dicaproate and triethylene glycol dicaprylate 6.75, 2-(o-chlorophenyl)-4,5-diphenylimidazolyl dimer 6.18, 1-(2'-nitro-4',5'-dimethoxyphenyl)-1-(4-methoxyphenoxy)ethane 2.81, 2,5-bis(4-diethylamino-2-methylbenzylidene)cyclopentanone 0.90, C.I. Solvent Red 109 0.95, leuco crystal violet 0.19, and 1,4,4-trimethyl-2,3-diazabicyclo(3.2.2.)non-2-ene N,N-dioxide 0.5 part in 2-ethoxyethanol was whirl coated on an anodized Al support, dried, overcoated with an aq. poly(vinyl alc.) soln. contg. a matting agent, exposed and developed to give a high-quality lithog. plate.

IT 38394-52-4

(photopolymerizable compns. contg. nitroarom. compd. photoinhibitor and, for printing plate fabrication and photoresists)

RN 38394-52-4 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)-2-methylphenyl]methylene](9CI) (CA INDEX NAME)

IC G03C; C08L; C08F

CC 74-2 (Radiation Chemistry, Photochemistry, and Photographic Processes)

Section cross-reference(s): 25

IT 106-10-5 603-48-5 1707-68-2 15625-89-5 25086-15-1 34122-40-2 **38394-52-4** 53802-03-2

(photopolymerizable compns. contg. nitroarom. compd. photoinhibitor and, for printing plate fabrication and photoresists)

L70 ANSWER 11 OF 13 HCA COPYRIGHT 2005 ACS on STN

- 80:114843 Photopolymerizable compositions containing cyclic cis-.alpha.-dicarbonyl compounds and selected sensitizers. Chang, Catherine T. (du Pont de Nemours, E. I., and Co.). U.S. US 3756827 19730904, 7 pp. (English). CODEN: USXXAM. APPLICATION: US 1972-220694 19720125.
- AB Photopolymerizable compns. of high photospeed consists of an ethylenically unsatd. monomer capable of photoinitiated addn. polymn. and photoinitiator combination of a cyclic cis-.alpha.-dicarbonyl compd., such as 2,3-norbornadione (I), 2,2,5,5-tetramethyltetrahydro-3,4-furandione, indole-2,3-dione, and

a radiation-absorbing compd. having a max. absorption at <520 nm capable of sensitizing the polymg. action of the above dicarbonyl compd., such as Michler's ketone (II), 3,3'-diethylthiacyanine p-toluenesulfonate, 4-(dimethylamino)benzoquinone, Acridine Orange, and optionally a free-radical producing H or electron donor compd. and a polymeric binder. Thus, a soln. contg. cellulose acetate 2.7, cellulose acetate butyrate 4.2, trimethylolpropane triacrylate 13.5, Me2CO 116, I 0.047, and II 0.047 g was coated on a poly(ethylene terephthalate) (III) support at 0.002 in. wet thickness, dried, laminated with a III cover sheet, exposed using a 1000-W W-lamp at 44 in. through an Eastman Kodak M-type no. 5 step tablet, and developed by dusting with Jungle Black to give an equiv. exposure time of 2 vs. .apprx.400 for a II-free control.

IT 38394-53-5 52560-25-5

(photosensitizer, for trimethylolpropane triacrylate photopolymerizable compns.)

RN 38394-53-5 HCA

CN Cyclopentanone, 2,5-bis[[4-(diethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

RN 52560-25-5 HCA

CN Cyclopentanone, 2,5-bis[3-[4-(dimethylamino)phenyl]-2-propenylidene](9CI) (CA INDEX NAME)

IC G03C

INCL 096086000P

CC 74-4 (Radiation Chemistry, Photochemistry, and Photographic Processes)

IT 65-61-2 90-93-7 90-94-8 91-44-1 92-99-9 100-10-7 102-71-6, uses and miscellaneous 103-01-5 530-44-9 603-35-0 1197-19-9 1628-58-6 2124-31-4 2465-27-2 6673-14-9

17087-90-0 19132-98-0 33458-29-6 35128-95-1 **38394-53-5** 52439-99-3 **52560-25-5**

(photosensitizer, for trimethylolpropane triacrylate photopolymerizable compns.)

L70 ANSWER 12 OF 13 HCA COPYRIGHT 2005 ACS on STN

73:50738 Dry process proof sheet. Druker, Leonard J.; Sachi, Leonard W. (Minnesota Mining and Manufacturing Co.). U.S. US 3515559 19700602, 2 pp. (English). CODEN: USXXAM. APPLICATION: US 1966-583432 19660930.

A photosensitive coating that is useful for proofing reproduction of AΒ pos. or neg. films or plates, and that may be handled in subdued light, is processed by exposure to uv radiation, followed by heat development. The coating contains a heat-developable Ag salt and a stabilizer, such as 2,6-bis(2-pyridylmethylene)cyclohexanone (I), 2,6-dicinnamylidenecyclohexanone (II), 2,6-bis[3(or 4)-pyridylmethylene]cyclohexanone, or (2-pyrid-2,5bispyridylmethylene)cyclopentanone. I and II may be prepd. by condensation of the corresponding aldehydes with cyclohexanone at 50-55.degree. in anhyd. EtOH in the presence of a basic catalyst. Crystals ppt. upon cooling. E.g., a mixt. contg. poly(vinyl butyral) 7.6, ZnO 15.5, Ag half soap (obtained by pptn. acidic AgNO3 and the aq. soln. of the Na salt of behenic acid) 8.9, toluene 23.5, acetone 44.5, and I 0.03 part, is uniformly blended in a ball mill, I being added during the final milling period, and the mixt. coated onto supercalendered white paper at a dry wt. of 1.4 g/ft2. coating contg. poly(vinylpyrrolidone) 4, hydroquinone 6, NH4Br 0.06, succinic acid 0.05, and MeOH 89.9 parts, is uniformly applied over the previous coating at a dry wt. of 0.2 g/ft2. sheet is contact-exposed through a photographic neg. by using a 140-A arc lamp at 4 ft for 1 min. The uncoated side is then contacted with a platen, held at 195.degree.F, for 10 sec to yield a sharp and clear pos. print of the photographic neg.

IT 29053-73-4

RN

(photographic stabilizer, for heat developable proof papers)
29053-73-4 HCA

CN Cyclohexanone, 2,6-bis(2-pyridinylmethylene) - (9CI) (CA INDEX NAME)

IC G03C INCL 096109000

CC 74 (Radiation Chemistry, Photochemistry, and Photographic Processes)
IT 29053-73-4

(photographic stabilizer, for heat developable proof papers)

L70 ANSWER 13 OF 13 HCA COPYRIGHT 2005 ACS on STN

50:69236 Original Reference No. 50:12890d-i,12891a-i,12892a The dipole moments, spectra, and structure of some new 2-phenyl-, 2-benzyl-, 2-(p-halobenzylidene)- and 2,6-bis(p-halobenzylidene)cyclohexanones. Huitric, Alain C.; Kumler, W. D. (Univ. of California, San Francisco). Journal of the American Chemical Society, 78, 614-22 (Unavailable) 1956. CODEN: JACSAT. ISSN: 0002-7863. OTHER SOURCES: CASREACT 50:69236.

p-BrC6H4CHO (37.5 g.) and 12.7 g. MeNO2 in 90 cc. MeOH treated AΒ dropwise with stirring at 10-15.degree. with 8.73 g. NaOH (25 cc. ice cold ag. soln.), the mixt. dild. with 20 cc. MeOH, stirred 15 min., treated with 150 cc. ice-water mixt., and added slowly with stirring to 50 cc. concd. HCl and 75 cc. H2O, and the ppt. washed with H2O gave 23 g. p-BrC6H4CH:CHNO2, yellow crystals, m. 150.1-51.degree. (from 95% EtOH); method A. Similarly were prepd. the following p-substituted .beta.-nitrostyrenes (I) (p-substituent, % yield, and m.p. given): p-Cl, 52, 113-14.degree.; p-O2N, 58, 206-7.degree. (from 95% EtOH-dioxane); p-I (II), 40, 188.5-9.5.degree.. p-IC6H4CHO (20 g.), 10.4 g. MeNO2, and 8 g. NH40Ac refluxed 2 hrs. in 80 cc. glacial AcOH, and the hot mixt. poured into 500 cc. ice-H2O mixt. yielded 14.3 g. II, yellow crystals, m. 188.5-9.5.degree. (from EtOH-dioxane); method B. Similarly was prepd. 41% p-iso-PrC6H4CH:CHNO2, m. 37-8.degree. (from iso-PrOH and petr. ether). p-Et2NC6H4CHO (17.7 g.) and 18.3 g. MeNO2 heated 5 min. on the water bath, treated with 0.5 g. AmNH2, heated 1 min., allowed to stand overnight, and cooled gave 6 q. p-Et2NC6H4CH:CHNO2 (III), bright red crystals, m. 96-7.degree. (from 95% EtOH). p-HOC6H4CH:CHNO2 (30 g.) and 90 g. AcCl kept 7 hrs. at 45.degree., and the excess AcCl removed in vacuo gave 24 g. p-AcOC6H4CH:CHNO2, light yellow crystals, m. 160-1.degree. (from 95% The appropriate I heated with (CH2:CH)2 75-90 hrs. at 100.degree. in a sealed reactor with PhMe as the solvent, the solvent removed under a stream of N or air at room temp., and the residue recrystd. gave the corresponding 4-nitro-5-(p-substituted phenyl)cyclohexene (IV) (p-substituent, % yield, and m.p. given): p-Cl, 89, 88.5-9.5.degree. (from EtOH, iso-PrOH); p-Br, 96, 110.6-11.5.degree. (from EtOH, iso-PrOH); p-I, 71, 145-6.degree. (from EtOH, iso-PrOH); p-NO2, 91, 138-9.degree. (from EtOH); p-AcO, 87 (in dioxane), 113.5-14.5.degree. (from EtOH, iso-PrOH); p-iso-Pr, 90, 75.0-5.5.degree. (from iso-PrOH, petr. ether). III (27 g.), 25 g. CC13CO2H, traces of hydroquinone, 35 cc. dioxane, and excess (CH2:CH)2 heated 82 hrs. at 100.degree. in a bomb, the dioxane removed in vacuo with N, the residue washed with 10% aq. Na2CO3 and 5% HCl to leave 13.5 g. unreacted III, the acid washings

neutralized with Na2CO3, the ppt. extd. with hot petr. ether, and the ext. evapd. gave 2.5 g. 4-nitro-5-(pdimethylaminophenyl)cyclohexene, orange crystals, m. 133-4.degree. (from iso-PrOH). The same reaction performed in dioxane with a slight excess of HCl gave a grayish black material, m. above 250.degree.; at room temp. in glacial AcOH during 1 week only unchanged III was recovered. The IV were converted by the method of Wildman and Wildman (C.A. 47, 1620a) to the corresponding 6-(p-substituted phenyl)-3-cyclohexen-1-ones (V) (p-substituent, % yield of crude V, m.p. of purified V, and m.p. of the 2,4-dinitrophenylhydrazone given): p-Cl, 38.5, 64-4.5.degree., 144.5-5.5.degree.; p-Br, 33, 63.5-4.5.degree., 149-50.degree.; p-I, 73, 62-3.degree., -; p-NO2 (VI), 53, 112.5-13.5.degree., 174.5-75.degree.; p-OH, 55, 126-7.degree., 214.5-15.5.degree.; p-iso-Pr, -, 66.5-7.5.degree., -. The V hydrogenated catalytically at room temp. over Raney Ni W-2 or 10% Pd-C gave the corresponding 2-(p-substituted phenyl)cyclohexanones (p-substituent, m.p. and catalyst given): p-Cl (VII), 77.5-8.5.degree. (from EtOH-petr. ether), Ni; p-Br (VIII), 84-5.degree. (from EtOH-petr. ether), Ni; p-iso-Pr (IX), 70.0-70.5.degree. (from aq. iso-PrOH), Ni (Pd); p-OH (X), 168.5-70.degree. (from 50% aq. EtOH), Ni. VI (2.5 q.) in 200 cc. 95% EtOH contq. 2.5 cc. concd. HCl hydrogenated 6 min. at 10 lb. pressure over 200 mg. 10% Pd-C, filtered, treated with 5 cc. concd. HCl, concd. to about 30 cc., dild. with 150 cc. dry Et20, and refrigerated overnight gave 2.4 g. 2-(p-aminophenyl)cyclohexanone (XI) HCl salt. XI.HCl (1.7 g.) in 4 cc. H2O and 1.5 cc. concd. H2SO4 cooled to 0.degree., treated with 4 g. crushed ice, diazotized at 10.degree. with 0.65 g. NaNO2 in 1.6 cc. H2O, the mixt. kept 10 min. in ice, treated with a small amt. of urea, and added dropwise to 100 cc. boiling N H2SO4, and the mixt. cooled deposited 1.2 g. X, m. 168.5-70.degree. (from 50% aq. EtOH). XI.HCl (1.7 g.) in 4 cc. H2O and 5 cc. concd. HCl treated dropwise at 0.degree. with 0.54 g. NaNO2 in 2 cc. H2O, the mixt. treated dropwise with stirring and cooling with 1.41 g. KI in 8 cc. H2O at 5.degree., the mixt. kept 1.5 hrs. in ice, warmed to room temp., and extd. with CHCl3, the CHC13 ext. worked up, the dark oily residue extd. with hot ligroine, and the ext. evapd. gave 1.2 g. 2-(p-iodophenyl)cyclohexanone, m. 96-7.degree. (from aq. EtOH). o-MeC6H4MgBr from 81 g. o-MeC6H4Br, 11.9 g. Mg, and 170 cc. dry Et20 (the reaction was started with 4 drops BuBr) treated with 47.5 g. 2-chlorocyclohexanone (XII) in 130 cc. dry Et20, the mixt. dild. with 175 cc. dry C6H6, the Et20 removed, the residue refluxed 7 hrs., cooled, poured into 300 cc. ice cold water, and acidified with 10% H2SO4, the aq. layer extd. with C6H6, and the combined C6H6 solns. worked up gave 20 g. 2-(o-methylphenyl)cyclohexanone (XIII), colorless crystals, bl 115-30.degree., m. 55.5-6.5.degree. (from petr. ether); it gave treated with Girard T reagent the 2,4-dinitrophenylhydrazone, m. 143.5-4.5.degree.. m-BrC6H4Me and XII gave similarly 26% m-isomer

(XIV) of XIII, b1 125-34.degree., m. 37-8.degree. (purified with Girard T reagent); 2,4-dinitrophenylhydrazone, m. 132-3.degree.. the same manner was prepd. the p-isomer (XV) of XIII, colorless crystals, m. 50.5-1.5.degree.; 2,4-dinitrophenylhydrazone, m. 153.5-4.5.degree. (a certain amt. of p,p'-bitolyl, m. 121-2.degree., is also obtained), p-ClC6H4CHO (21 g.) and 7.35 g. cyclohexanone (XVI) in 150 cc. 50% EtOH contg. 0.9 g. NaOH refluxed 1.5 hrs. and cooled gave 23.6 g. 2,6-bis-(p-chlorobenzylidene)cyclohexanone (XVII), m. 147-8.degree. (from EtOH-C6H6). p-BrC6H4CHO (6.0 g.) and 1.59 g. XVI gave similarly 6.5 g. Br analog (XVIII) of XVII, bright yellow crystals, m. 166-7.degree. (from EtOH-C6H6). p-IC6H4CHO (10 g.) and 2.11 g. XVI in 200 cc. 50% EtOH refluxed 1.5 hrs. with 0.6 g. NaOH gave 9.5 g. p-I analog (XIX) of XVII, bright yellow crystals, m. 190.5-1.5.degree. (from EtOH-C6H6). XVII (5 g.) in 125 cc. C6H6 and 25 cc. abs. EtOH hydrogenated 1 hr. at 30 lb. pressure over 1.5 g. Raney Ni gave 4 g. 2,6-bis(p-chlorobenzyl)cyclohexanone (XX), colorless needles, m. 146-7.degree. (from 95% EtOH and iso-PrOH). XVIII (3.5 g.) gave similarly the Br analog of XX, colorless crystals, m. 154-5.degree. (from 95% EtOH and MeOH). p-Me2NC6H4CHO (10 g.) and 3.2 g. XVI refluxed 3 hrs. in 150 cc. 50% EtOH with 3 g. NaOH yielded 7.5 g. Me2N analog (XXI) of XVII, dark orange crystals, m. 246-8.degree. (from PhMe). p-Me2NC6H4CHO (2 equivs.) refluxed with 1 equiv. XVI in 50% EtOH contg. 0.3% NaOH gave only 12.5% XXI; the filtrate dild. with H2O gave a considerable amt. lower melting material, m. 66-8.degree.. XXI (1 g.) in 150 cc. EtOH, 6 cc. concd. HCl, and 15 cc. H2O hydrogenated 15 min. at 20 lb. pressure and room temp. over 200 mg. 10% Pd-C, filtered, neutralized with 10% aq. Na2CO3, and dild. with an equal vol. H2O gave Me2N analog of XX, m. 136-7.degree.. 4-Nitro-5-(pacetoxyphenyl)cyclohexene (1 g.) in 200 cc. abs. EtOH hydrogenated 15 min. at 30 lb. and room temp. over 0.1 g. 10% Pd-C, filtered, and evapd. in vacuo gave 2-(p-acetoxyphenyl)nitrocyclohexane, colorless crystals, m. 92-3.degree. (from 95% EtOH). The dipole moments were detd. for the following compds.: VII 4.25, VIII 4.11, IX 2.93, X 3.28, XV 2.91, XIV 2.99, XIII 3.31, 2-(p-chlorobenzyl)cyclohexanone 3.31, XX 3.03, 2-(p-chlorobenzylidene)cyclohexanone (XXII) 2.75, Br analog of XXII 2.89, iodo analog of XXII 2.76, XVII 2.23, XVIII 2.29, XIX 2.31. The ultraviolet absorption max. of all these compds. are tabulated.

IT 18977-38-3, Cyclohexanone, 2,6-bis(p-dimethylaminobenzylidene)-

(prepn. of)

RN 18977-38-3 HCA

CN Cyclohexanone, 2,6-bis[[4-(dimethylamino)phenyl]methylene]- (9CI) (CA INDEX NAME)

CC 10 (Organic Chemistry) IT 18977-38-3, Cyclohexanone, 2,6-bis(p-18984-24-2, Phenol, p-(2-nitrovinyl)-, dimethylaminobenzylidene) -18989-82-7, Cyclohexanone, 2,6-bis(p-chlorobenzylidene)acetate 24765-19-3, Cyclohexanone, 2,6-bis(p-bromobenzylidene)-24801-27-2, Cyclohexanone, 2,6-bis(p-iodobenzylidene)-25115-73-5, Cyclohexanone, 2-(p-chlorophenyl) - 29194-14-7, Styrene, 32045-66-2, Cyclohexanone, 2-m-tolylp-chloro-.alpha.-nitro-52776-14-4, Cyclohexanone, 2-p-tolyl- 63882-42-8, Cyclohexanone, 64462-51-7, Aniline, N, N-diethyl-p-(2-nitrovinyl)-2-o-tolyl-84604-97-7, Cyclohexanone, 2-p-cumenyl- 90196-47-7, Styrene, p,.alpha.-dinitro-91720-92-2, Cyclohexanone, 2-(p-bromophenyl)-92577-05-4, Cyclohexene, 4-(p-chlorophenyl)-5-nitro-97078-84-7, Cyclohexanone, 2-o-tolyl-, 2,4-dinitrophenylhydrazone 100063-28-3, 3-Cyclohexen-1-one, 6-(p-nitrophenyl)- 100389-81-9, Cyclohexanone, 2-(p-aminophenyl)-102082-24-6, Cyclohexanone, 2-p-tolyl-, 105640-25-3, Cyclohexanone, 2,4-dinitrophenylhydrazone 110049-85-9, Cyclohexanone, 2-(p-hydroxyphenyl)-182196-32-3, Cyclohexanone, 2,6-bis(p-chlorobenzyl)-2,6-bis(p-dimethylaminobenzyl) - 412314-52-4, Aniline, N, N-dimethyl-p-6-nitro-3-cyclohexen-1-yl- 838826-66-7, Cyclohexanone, 2-(p-iodophenyl) - 854714-99-1, Cyclohexanone, 2-(p-aminophenyl)-, hydrochloride 854717-99-0, Cyclohexanone, 2-m-tolyl-, 2,4-dinitrophenylhydrazone 854719-28-1, Cyclohexene, 4-(p-bromophenyl)-5-nitro- 854726-66-2, 3-Cyclohexen-1-one, 6-(p-nitrophenyl)-, 2,4-dinitrophenylhydrazone 854726-85-5, 3-Cyclohexen-1-one, 6-p-cumenyl- 854726-87-7, 3-Cyclohexen-1-one, 6-(p-chlorophenyl)-, 2,4-dinitrophenylhydrazone 854726-89-9, 3-Cyclohexen-1-one, 6-(p-chlorophenyl)-854726-91-3, 3-Cyclohexen-1-one, 6-(p-bromophenyl)-854727-14-3, 3-Cyclohexen-1-one, 6-(p-iodophenyl)-854727-16-5, 3-Cyclohexen-1-one, 6-(p-hydroxyphenyl)-, 2,4-dinitrophenylhydrazone 854727-18-7, 3-Cyclohexen-1-one, 6-(p-hydroxyphenyl)-854901-99-8, Cyclohexanone, 2,6-bis(p-bromobenzyl) - 854913-01-2, 3-Cyclohexen-1-one, 6-(p-bromophenyl)-, 2,4-dinitrophenylhydrazone 855419-28-2, Phenol, p-6-nitro-3-cyclohexen-1-yl-, acetate 856183-47-6, 855601-11-5, Phenol, p-2-nitrocyclohexyl-, acetate Cumene, p-6-nitro-3-cyclohexen-1-yl- 858467-40-0, Styrene, p-bromo-.alpha.-nitro- 858467-88-6, Styrene, p-isopropyl-.alpha.-